A scanning electron micrograph (SEM) of a microfluidic chip. The chip features various microstructures, including circular patterns and linear channels. A large, dark, multi-segmented insect, possibly a beetle, is positioned on the chip, providing a sense of scale. The background is a light gray, textured surface.

Miniaturization

(of analytical instrumentation)

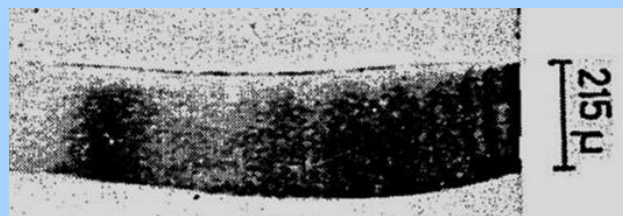
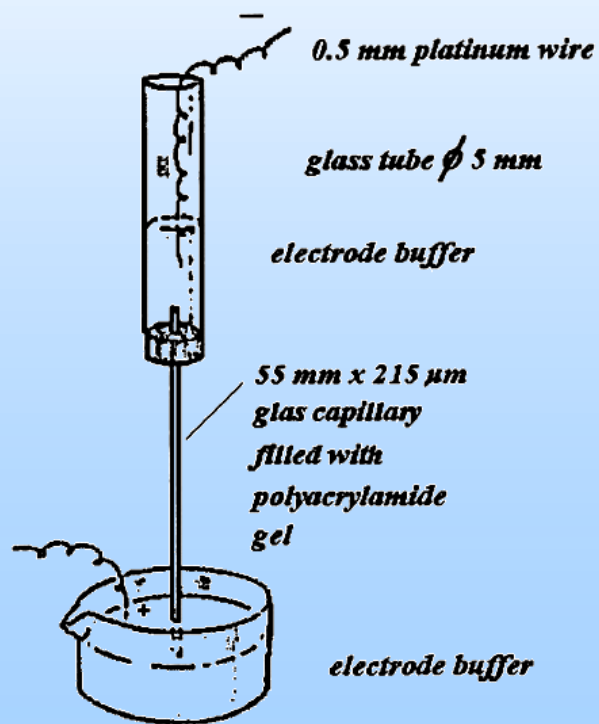
Introduction – history

Microfluidics

Applications for mass spectrometry

Miniaturized MS ...

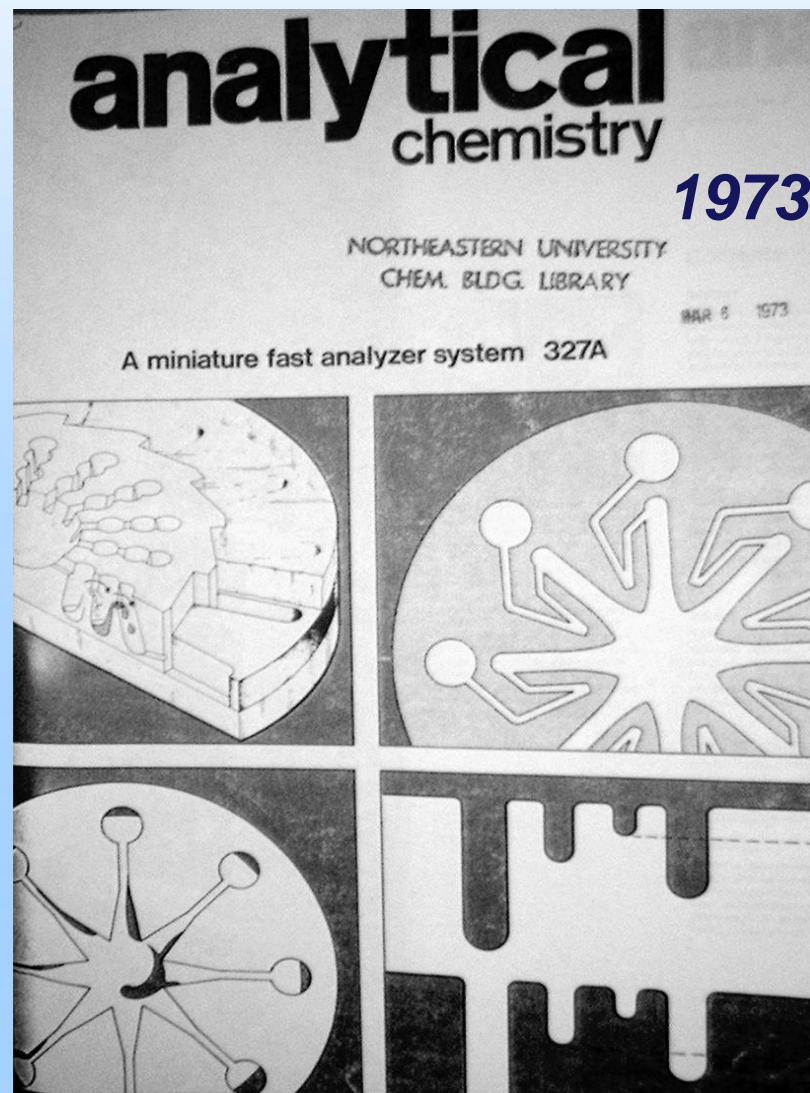
Instrumentation Miniaturization



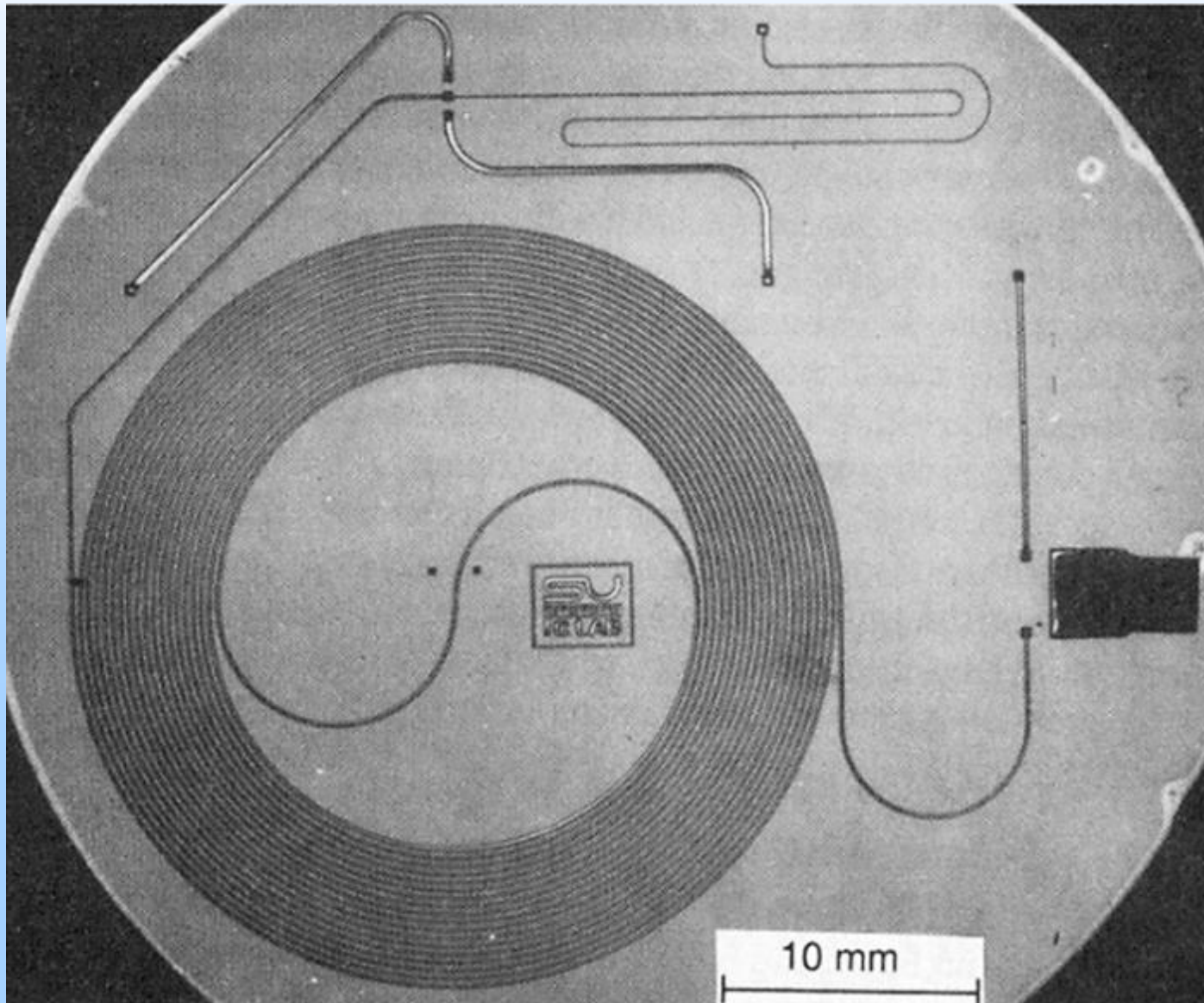
Capillary gel electrophoresis

Separation of nerve cell proteins

H. Hydén et al. Anal.Biochem, 17, 1-15, 1966.



A Gas Chromatographic Air Analyzer Fabricated on a Silicon Wafer



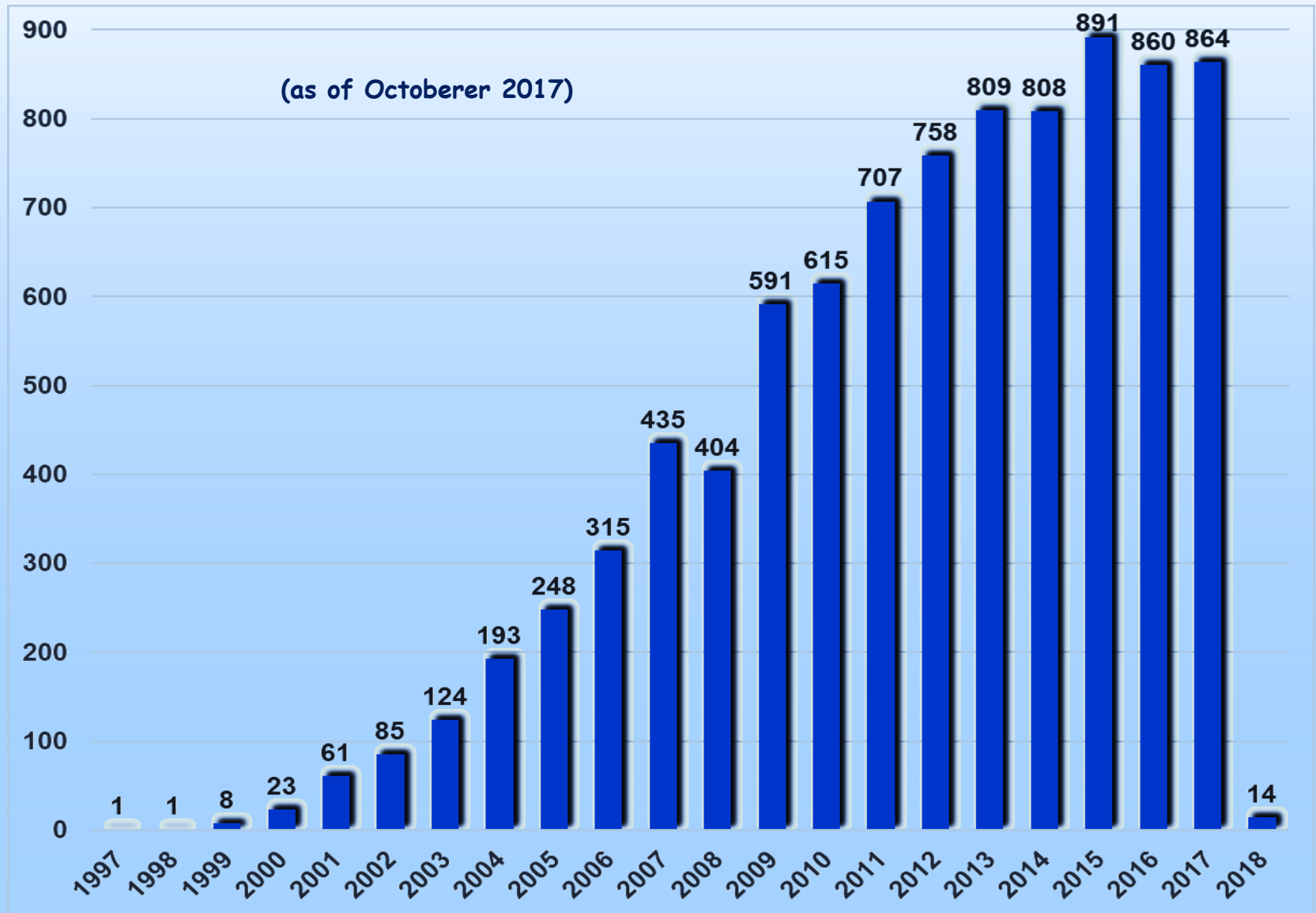
There really is nothing new under the Sun

Prototype analog pneumatic computer to operate in a nuclear attack
NBS (now NIST) 1950's



Picture by Wyatt Vreeland, NIST

Incidence of the word "MICROFLUIDIC" in PubMed



<https://www.ncbi.nlm.nih.gov/pubmed?term=Microfluidic%5BTitle%5D>

Microfluidics?

Microelectronics

Control of electric current



Microfluidics

control of fluid flows



Technology



Products



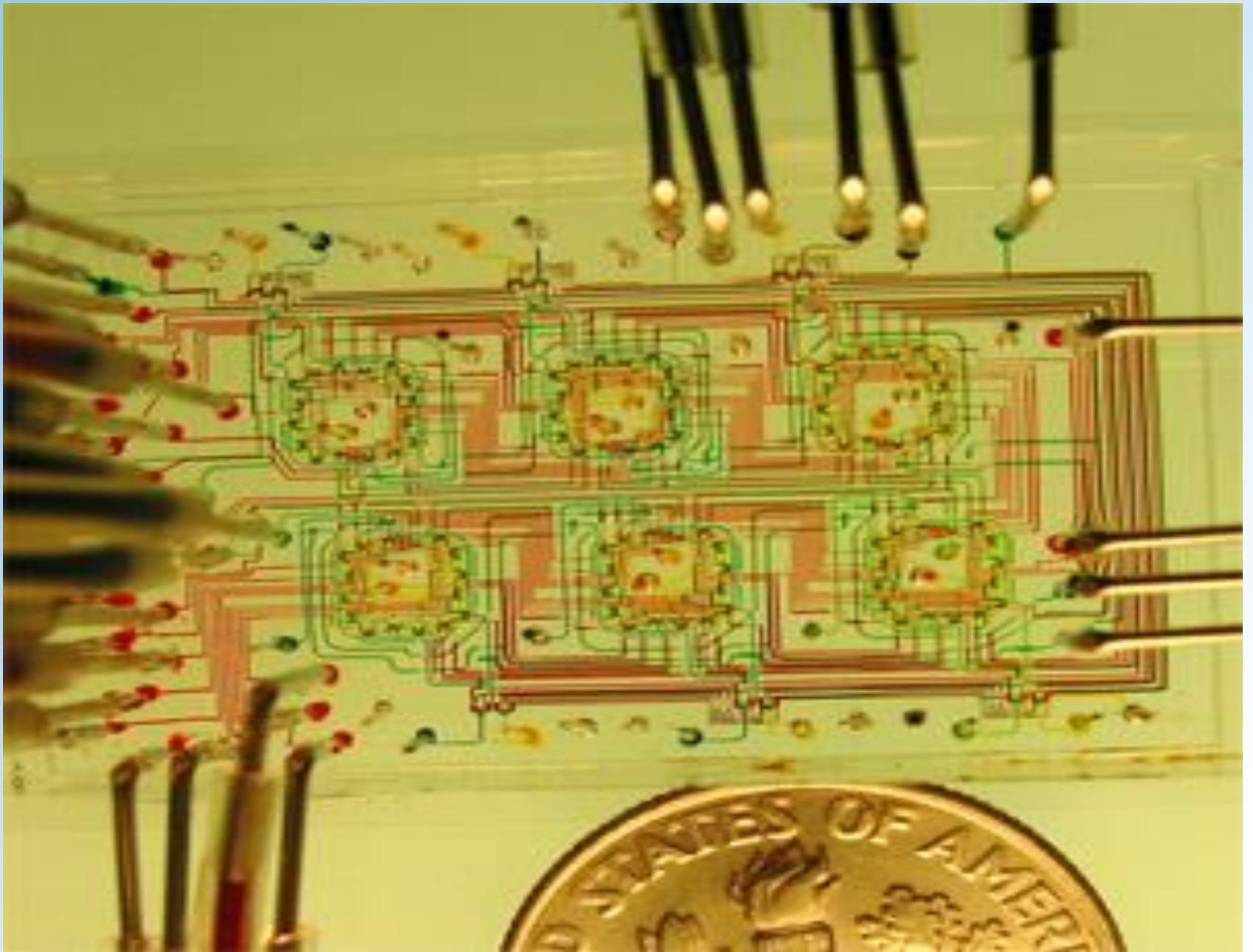
Consequences

Speed of analysis

Space saving

Cost cutting

Mass production



Stephen Quake, Dept. Bioengineering, Stanford University, <http://thebigone.stanford.edu/index.html>

Microfabrication technology

Micromilling 10 μm

Optical lithography 200 nm

e/ion beam lithography

Multiple exposure techniques 10 nm

Etching (resist dependent) ~ nm

Replication (mass production) 10's nm

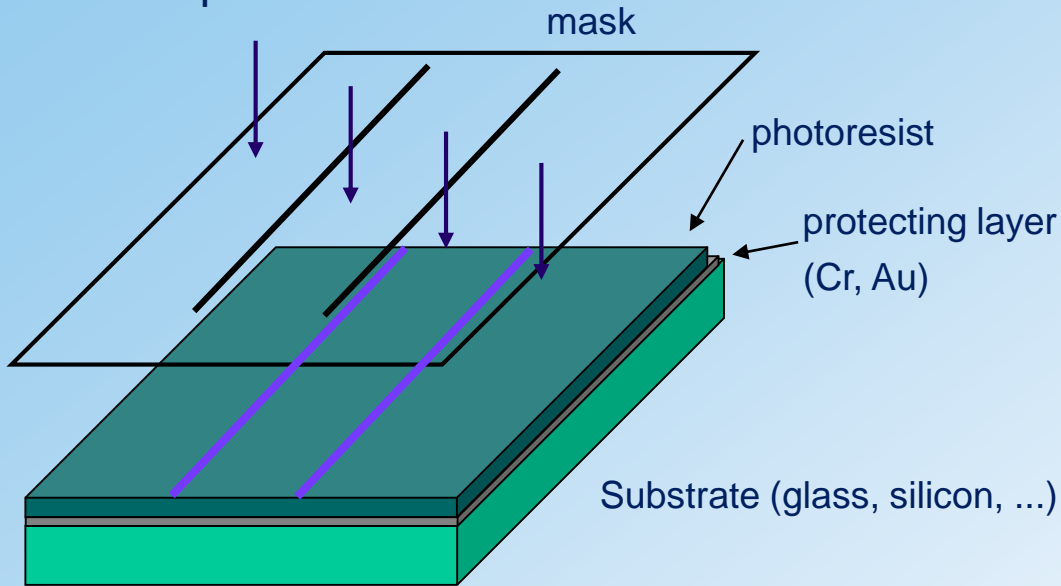
Injection molding

Hot embossing

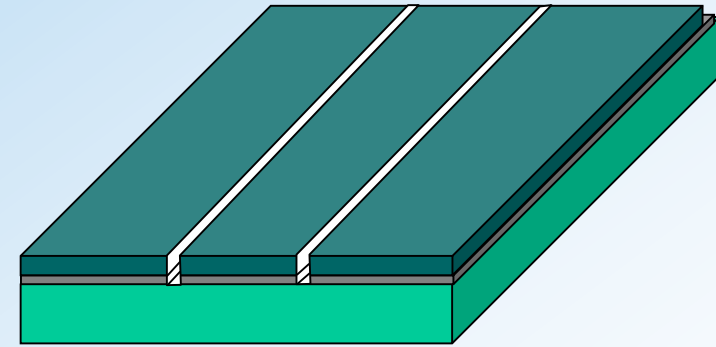
Casting

Photolithography

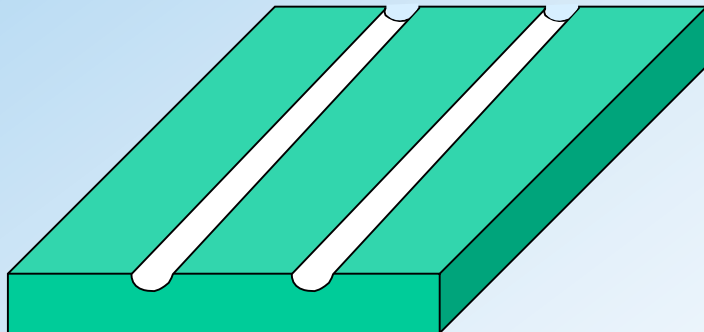
1. Expose



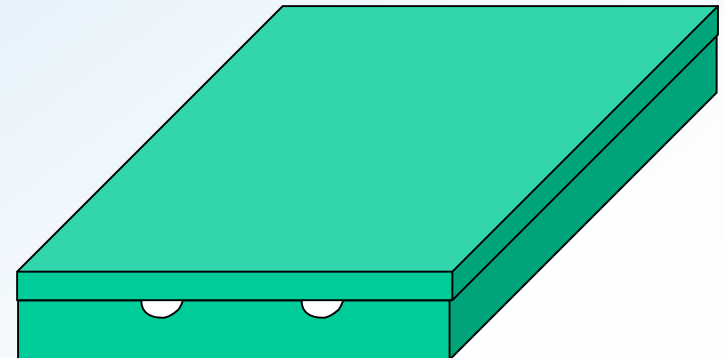
2. develop and etch



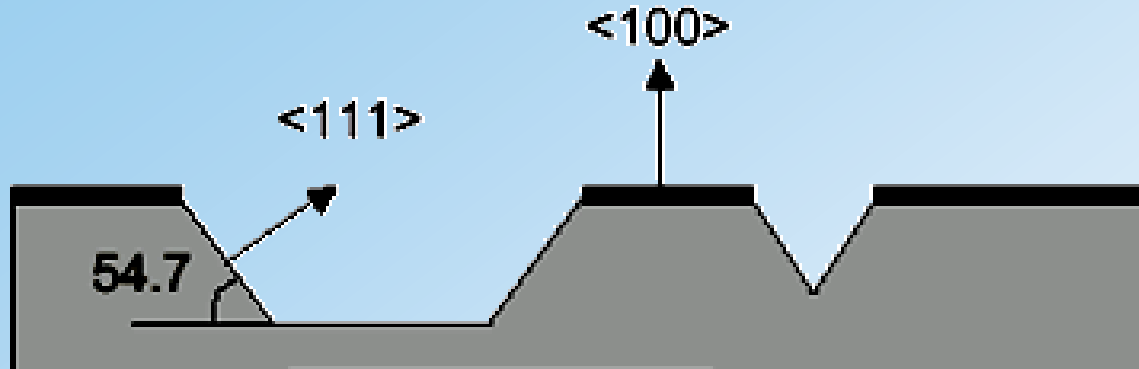
3. Remove the protection layer



4. Close the structure
(thermal bonding)



SILICON - ANISOTROPIC ETCHING



- * Anisotropic etching – direction dependent etch rate
- * Etch rate slower perpendicularly to the crystalline planes with the highest density
- * Typical etches: KOH, Tetramethyl Ammonium Hydroxide (TMAH)
Ethylene Diamine Pyrocatechol (EDP)

Making and inspecting semiconductor chips requires pushing laser techniques deeper into the ultraviolet.

by Hank Hogan, Contributing Editor



As semiconductor feature sizes shrink, manufacturers need a light touch — and at the right wavelength. A look at three areas — lithography, metrology and assembly — shows how photonics-based innovations are tackling some of the semiconductor industry's most pressing problems.

Steppers are among the most critical tools used for semiconductor manufacturing and are at the heart of the photolithographic process, which transfers the features that are on a mask onto the photoresist material on a wafer. Subsequent processing reproduces that transferred layout in layers of conductors and insulators that eventually comprise a functioning integrated circuit. Today, state-of-the-art features are as small as 65 nm. Soon, they will be 45 nm, and the generation beyond that, 32 nm. The latter two scales are several years away, although the equipment needed for them is being rolled out now.

Although designed for manufacturing on a microscopic scale, the latest lithography stepper lens from Carl Zeiss SMT AG of Oberkochen, Germany, is not small. The Starlith 1900i weighs more than a metric ton, stands several feet tall and is as big around as a tree trunk. A catadioptric lens consisting of reflecting mirrors and refractive optics, it enables volume semiconductor production

The device pictured is a catadioptric lens that, according to the manufacturer, can achieve 40-nm-resolution lithography on semiconductor chips. Courtesy of Carl Zeiss SMT.

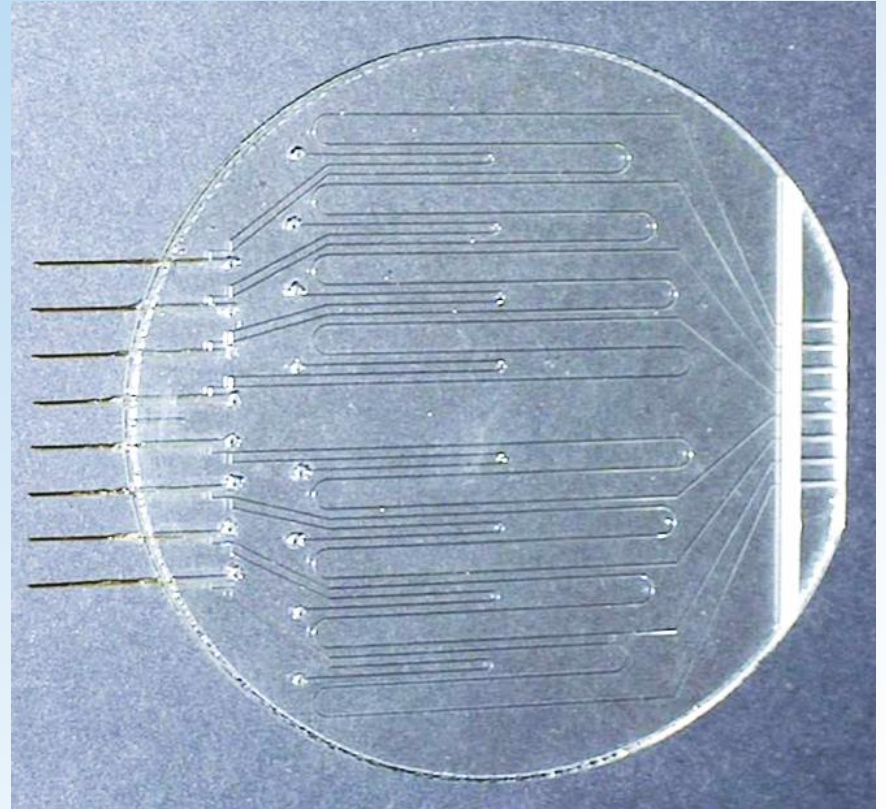
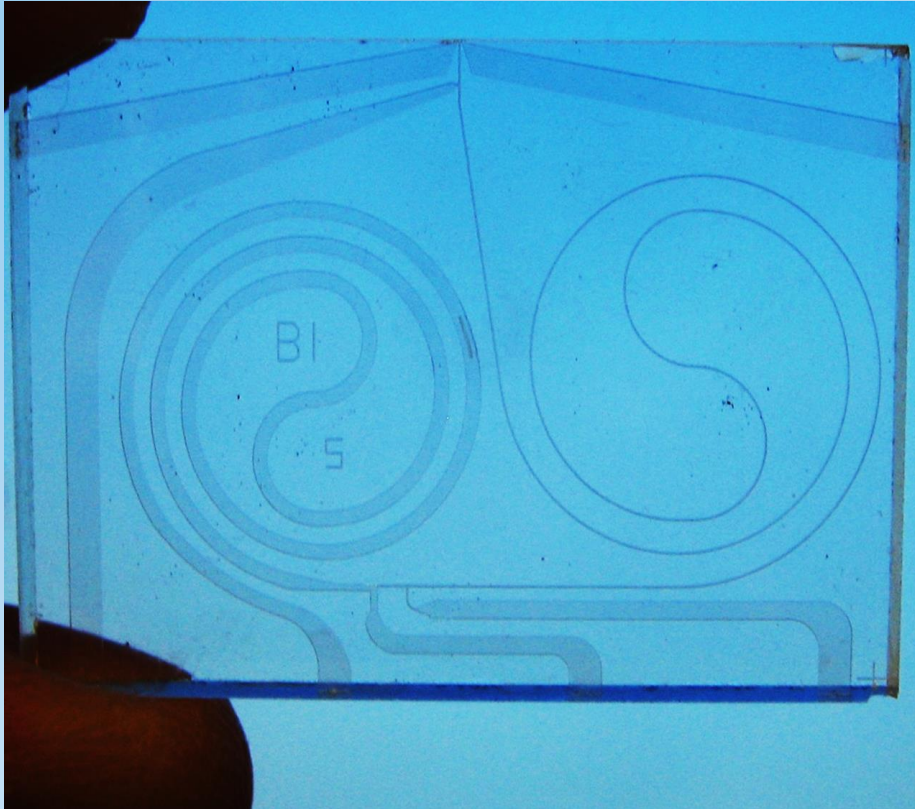
μPG 101 Tabletop Laser Pattern Generator

HEIDELBERG
INSTRUMENTS

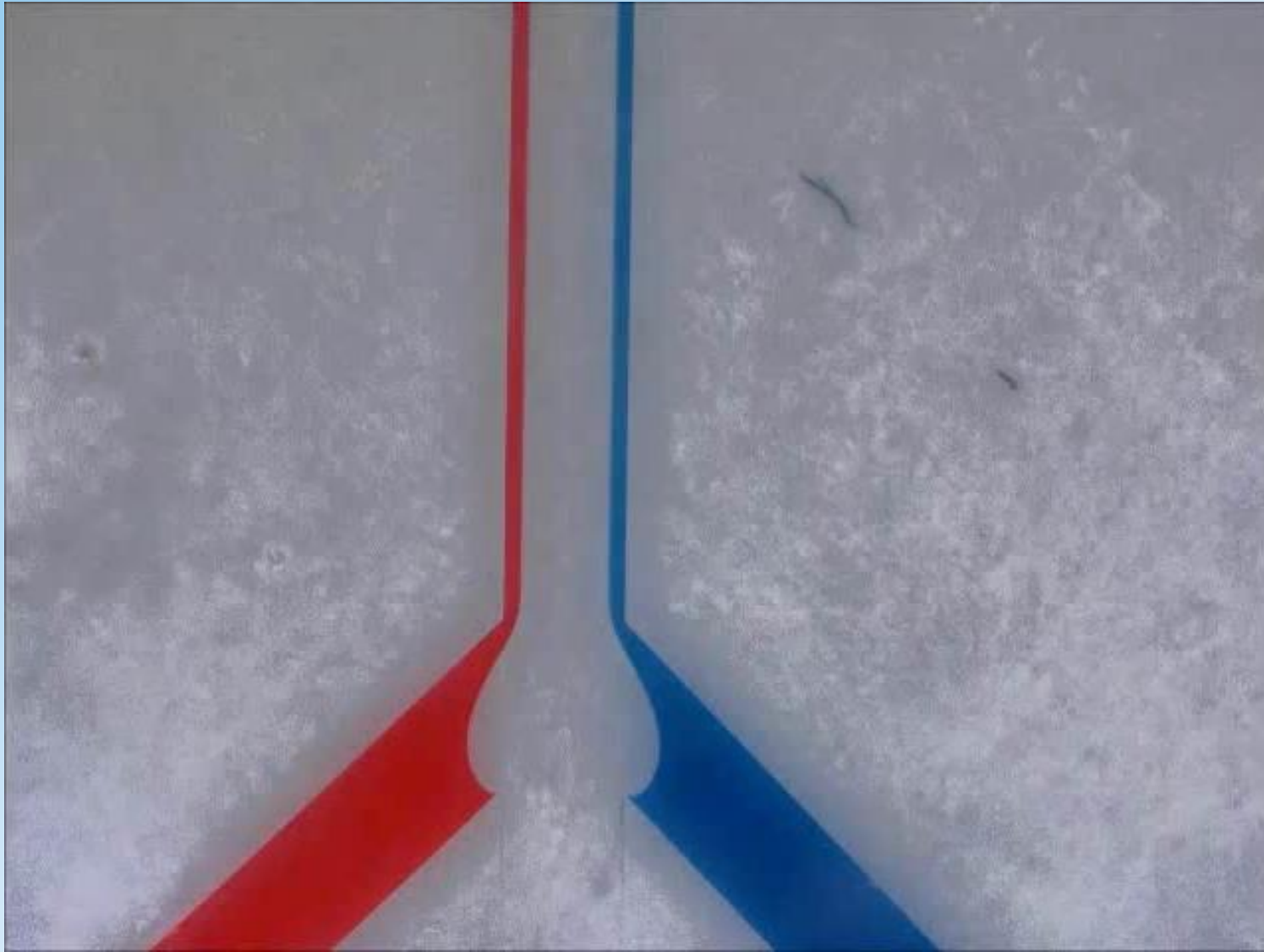


- Substrates up to 100 x 100 mm²
- Structures down to 1 μm
- Address grid down to 40 nm
- Standard or UV laser source

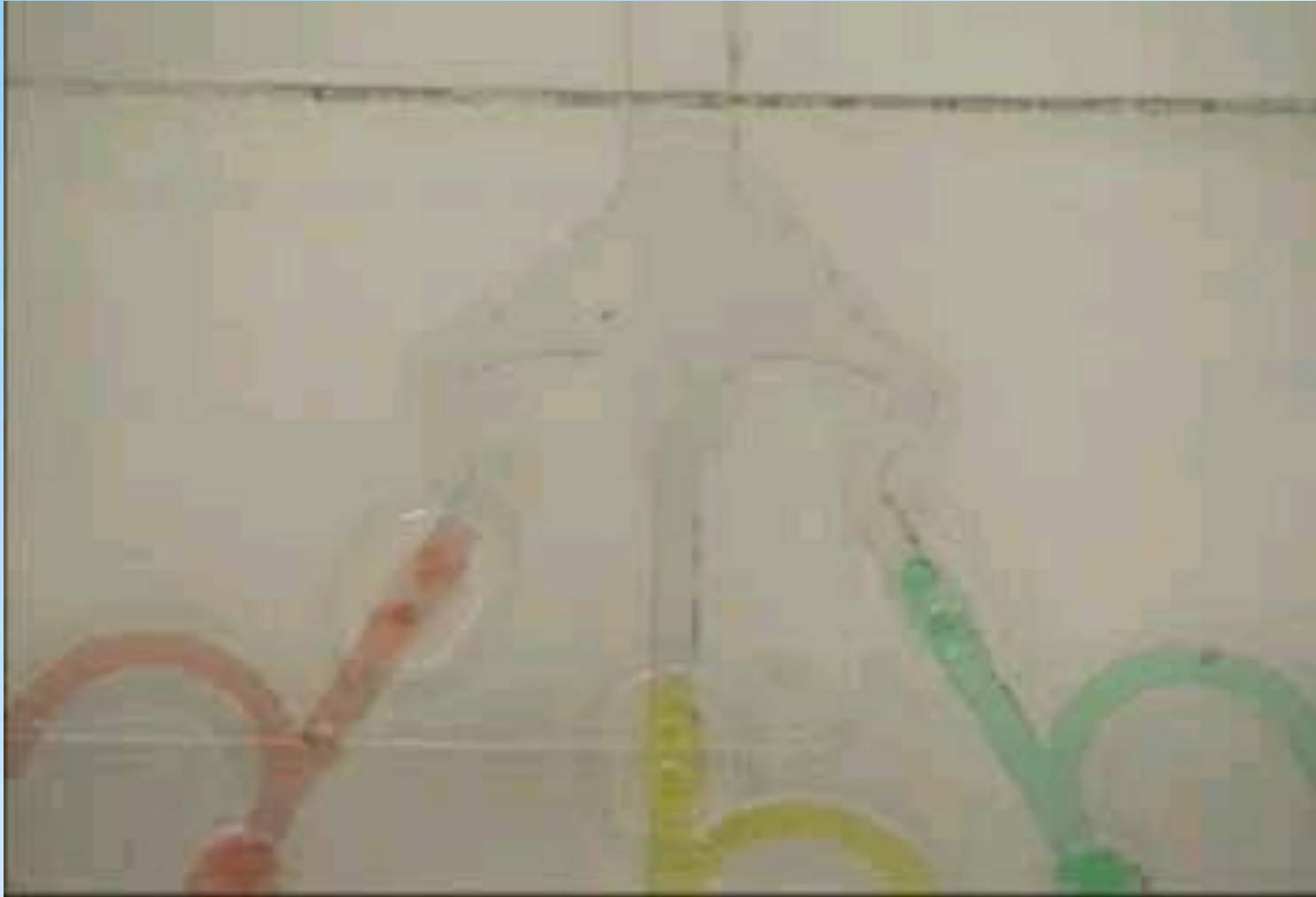
System Integration



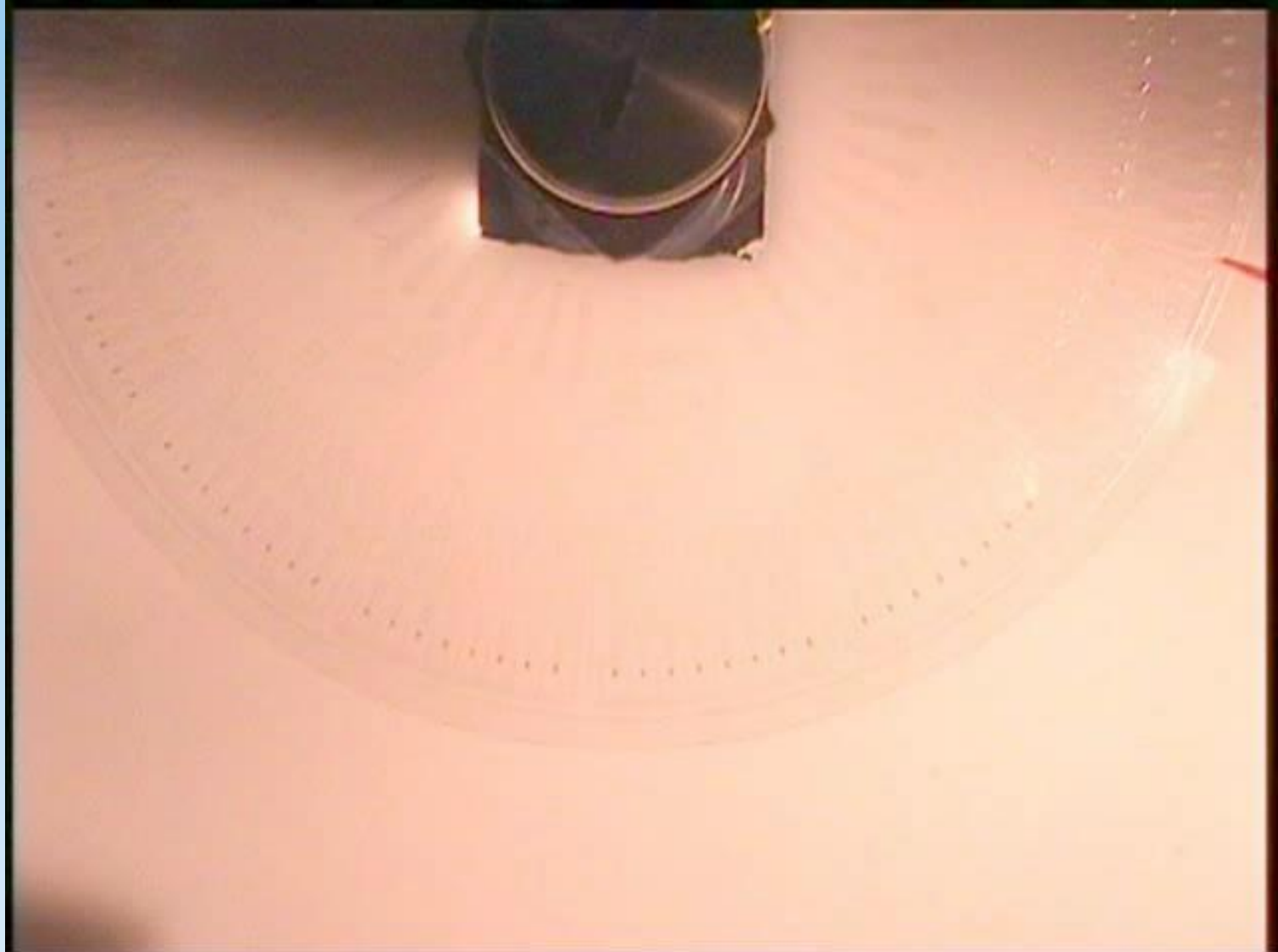
Spatial flow focusing



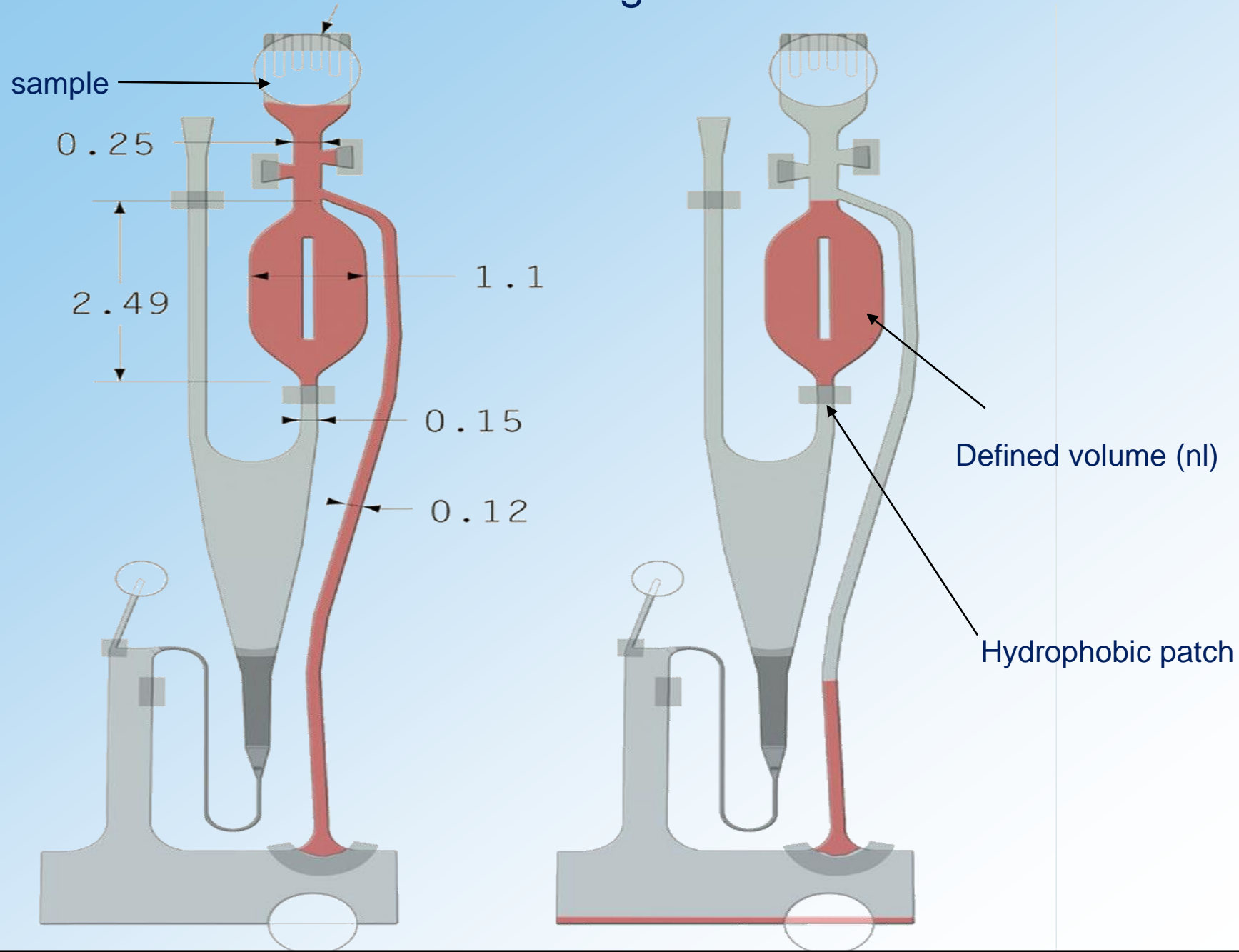
Diffusion limited mixing



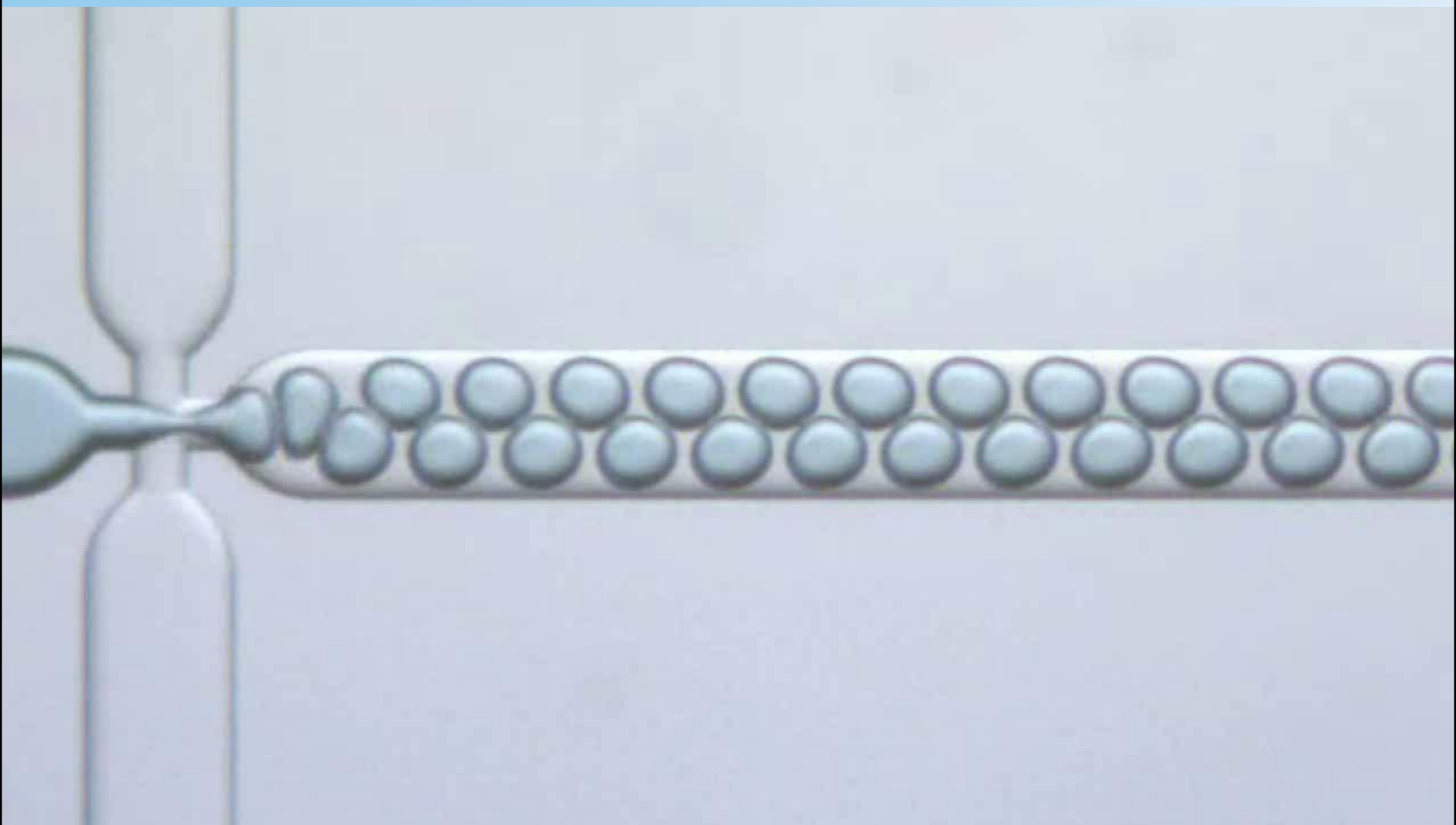
Capillary force filling



Exact volume metering on the nl level



Droplet generation in nl-pl volumes



<http://www.dolomite-microfluidics.com/>

Seth Fraden et al., J. AM. CHEM. SOC. 2007, 129, 8825-8835.

Benefits and Issues

Size - space saving

Low reagent/sample consumption

Smaller size – faster analysis

Microchannel junctions without dead volume

Parallel systems for high throughput

Disposable parts - point-of-care devices

BUT

Scaling issues

Fabrication limitations

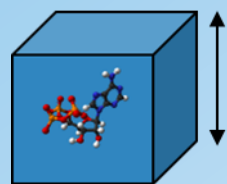
Surface chemistry

Concentration limits of detection

Phenomena unimportant on the macro scale may dominate

Small volume problem

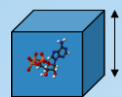
Example: LOD = 1000 molecules



2.15 mm

=>

10 μl \sim 10^{-15} M



1 mm

=>

1 μl \sim 10^{-14} M



0.1 mm

=>

1 nL \sim 10^{-11} M



0.001 mm

=>

1 fL \sim 10^{-5} M

MICROFABRICATED DEVICES

- * **Sensors** - accelerometers, glucose monitors, ...
- * **Genomics** - first commercial applications
- * **Proteomics** - sample processing
separation

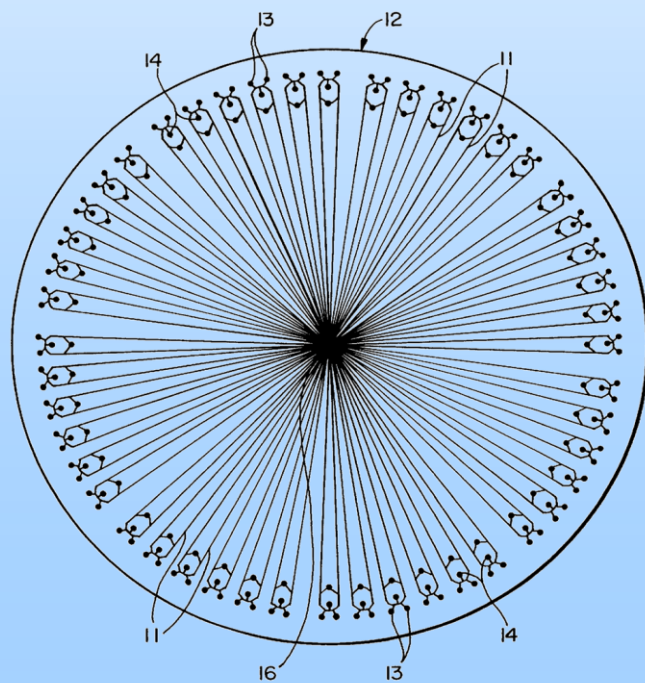
Radial Capillary Array Electrophoresis Microplate and Scanner for High-Performance Nucleic Acid Analysis.

U.S. Patent

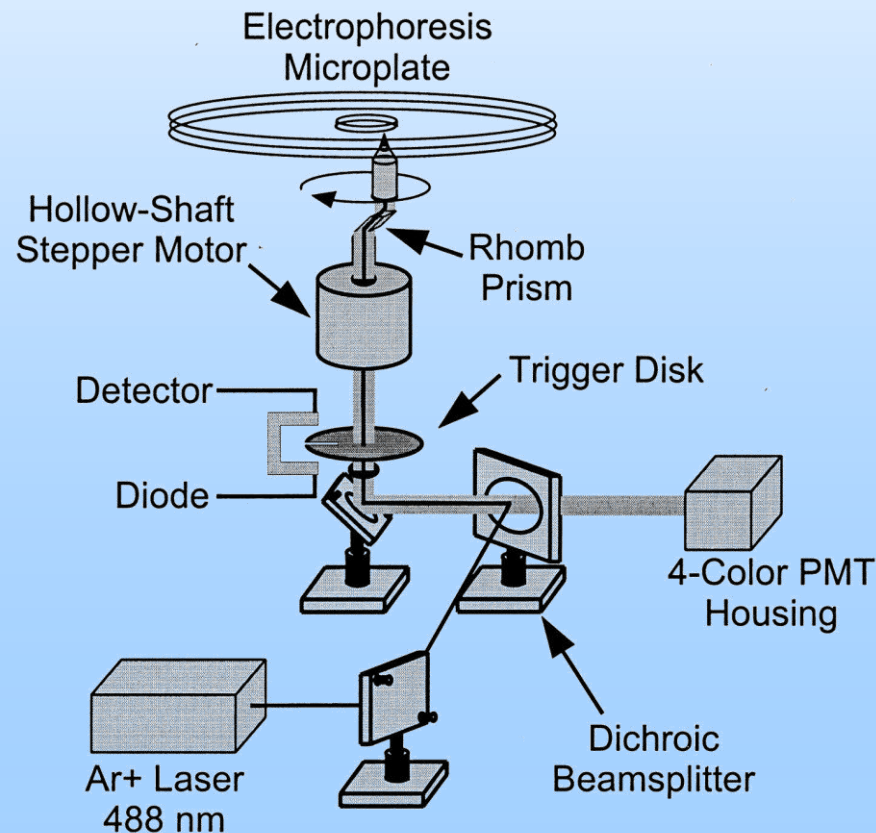
Aug. 8, 2000

Sheet 1 of 6

6,100,535



FIG_1



Yining Shi, Peter C. Simpson, James R. Scherer, David Wexler, Christine Skibola, Martyn T. Smith, and Richard A. Mathies. *Anal. Chem.* 1999, 71, 5354-5361

Microscale Fluid Handling System

U.S. Patent

Feb. 16, 1999

Sheet 1 of 15

5,872,010

U.S. Patent

Feb. 16, 1999

Sheet 4 of 15

5,872,010

U.S. Patent

Feb. 16, 1999

Sheet 6 of 15

5,872,010

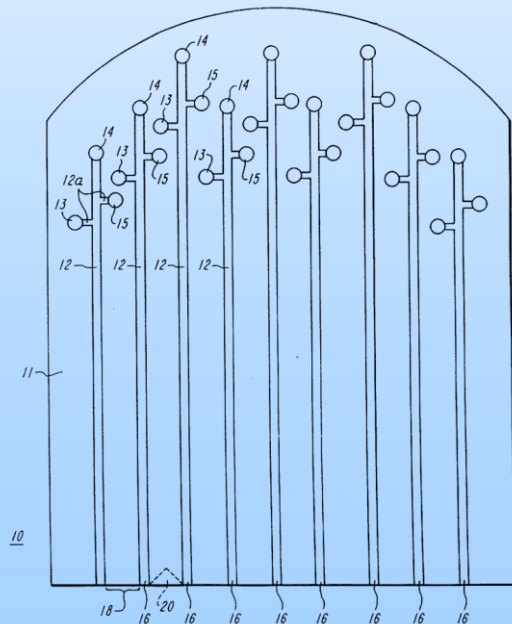


FIG. 1A

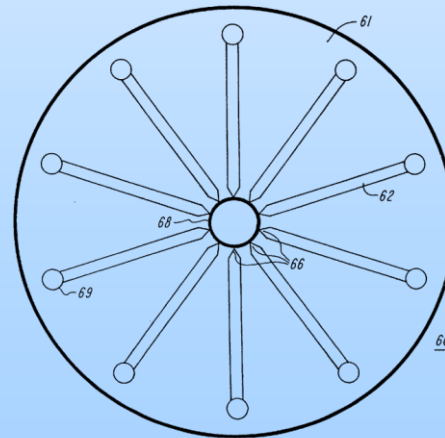


FIG. 3

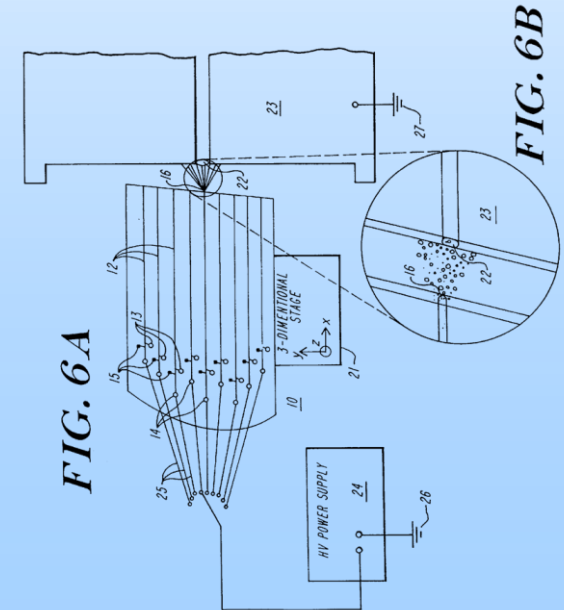
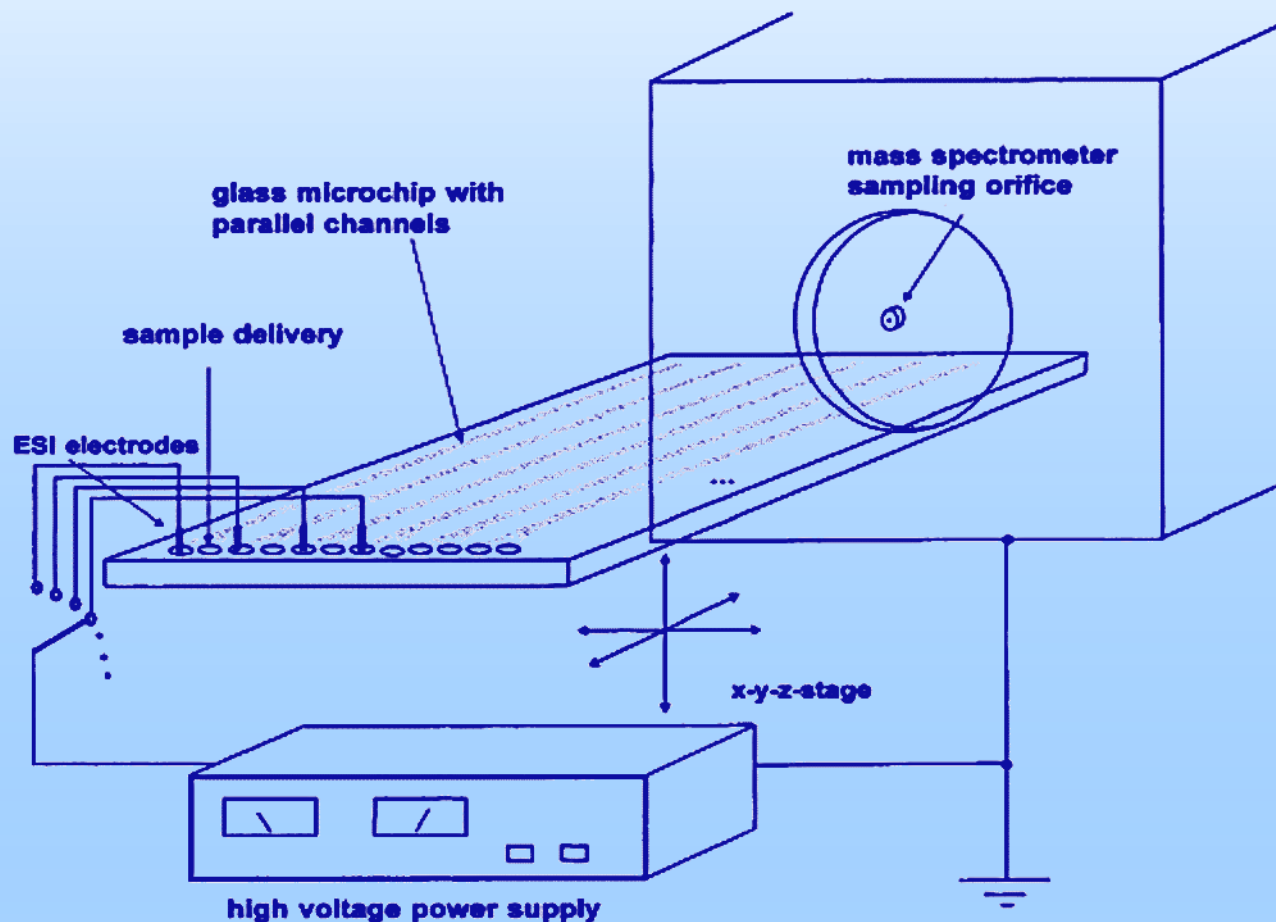


FIG. 6A

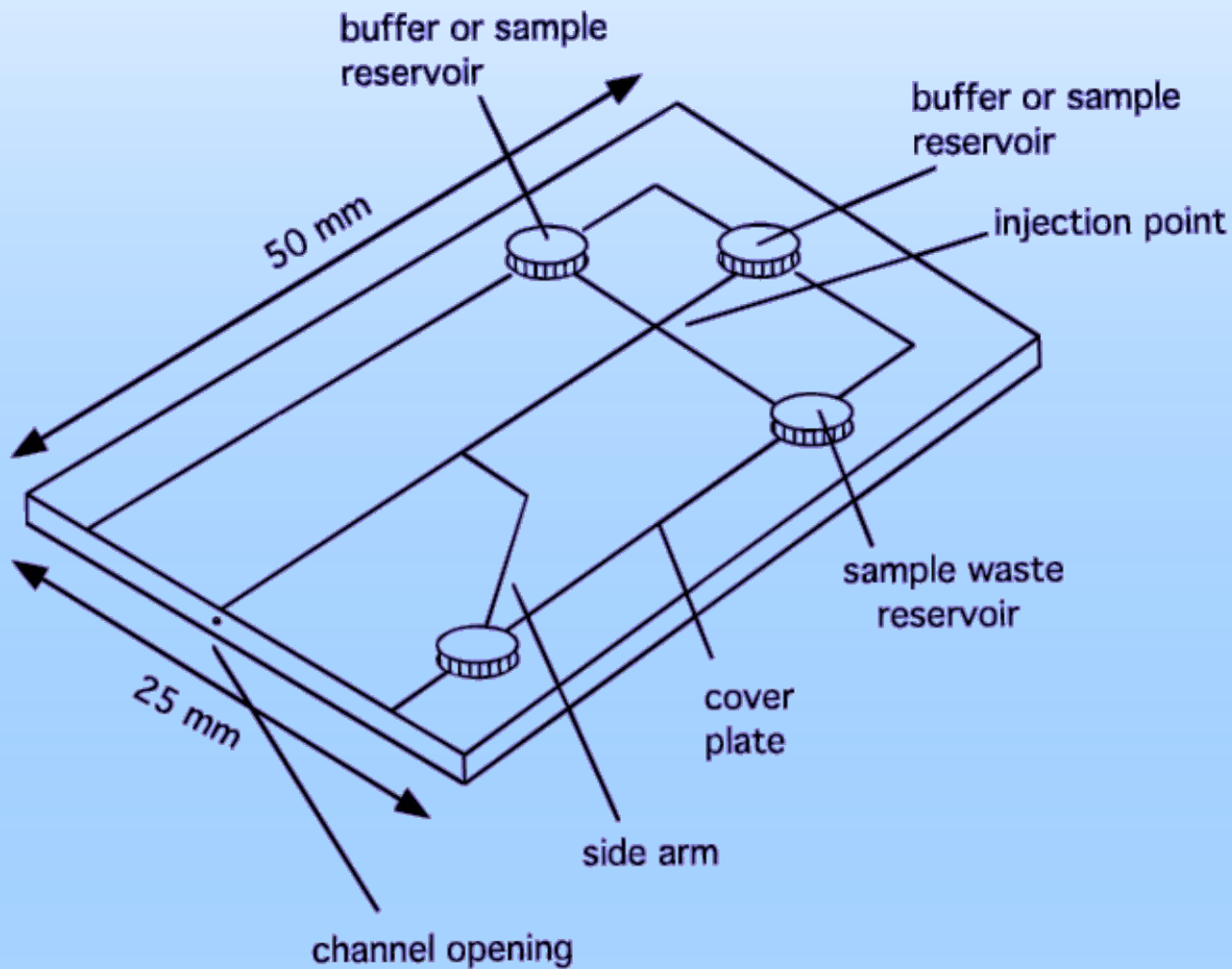
FIG. 6B

What is claimed is: 1. A liquid handling system, comprising a microscale liquid handling substrate having one or more channels integrally formed therein, for conducting a liquid sample in said substrate, said one or more channels terminating in one or more exit ports in an outer surface of said substrate for transfer of a microscale quantity of a liquid sample off said substrate by **droplet, spray or stream**;

Multichannel Microchip Electrospray Mass Spectrometry



Generating Electrospray from Microchip Devices Using Electroosmotic Pumping



Electrospray



Flat surface - droplet



Capillary tip

ESI tip (micro)fabrication ?

Grinding

Etching, pulling, ...

Original capillary

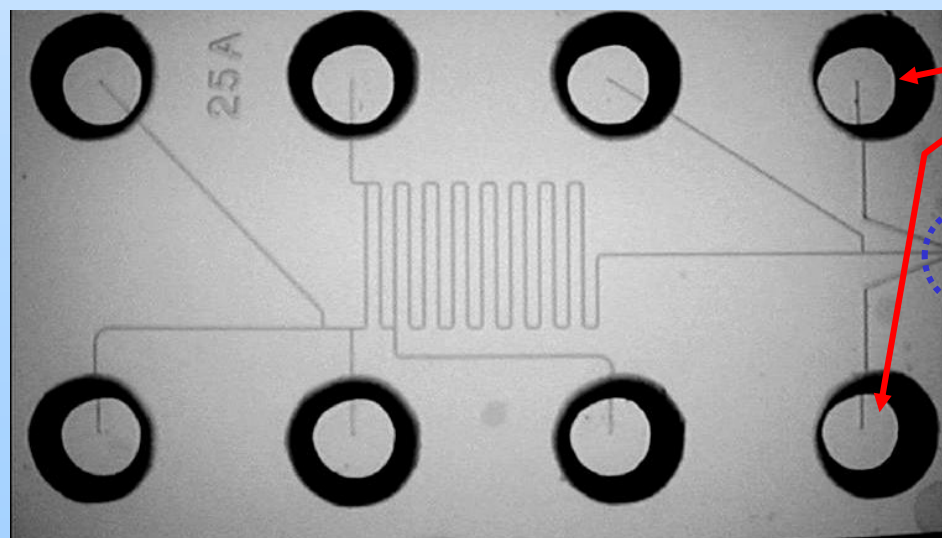


CE Microdevice with a Pneumatic Nebulizer

sample

spray fluid

nebulizer gas



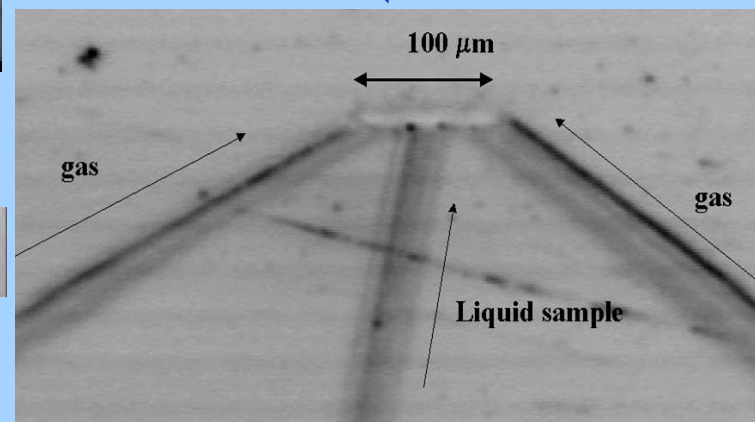
ESI exit

BGE

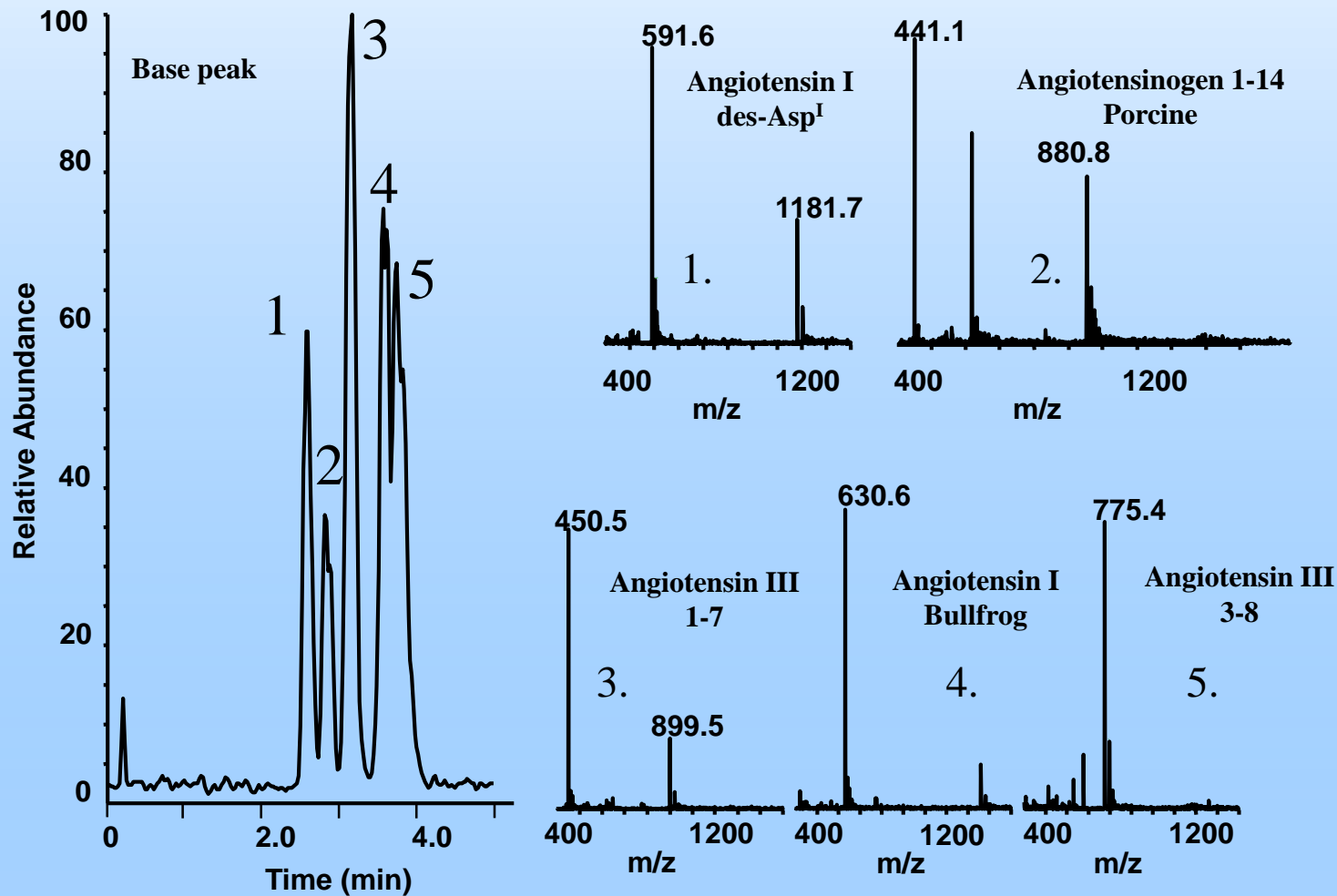
waste



10 mm

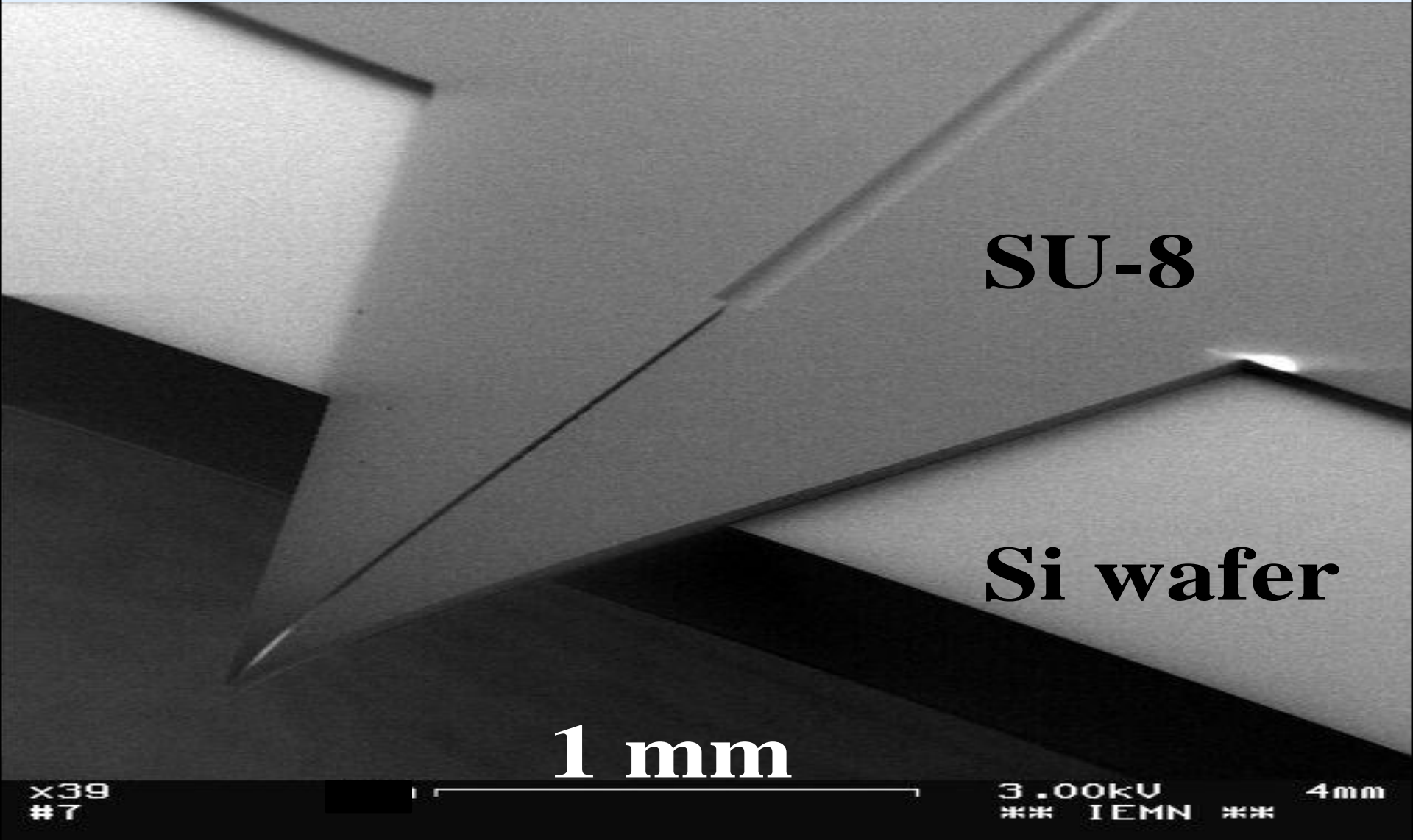


CE Microdevice with a Pneumatic Nebulizer



Micro-nib electrospray source

(SU-8 on a silicon wafer)



SU-8

Si wafer

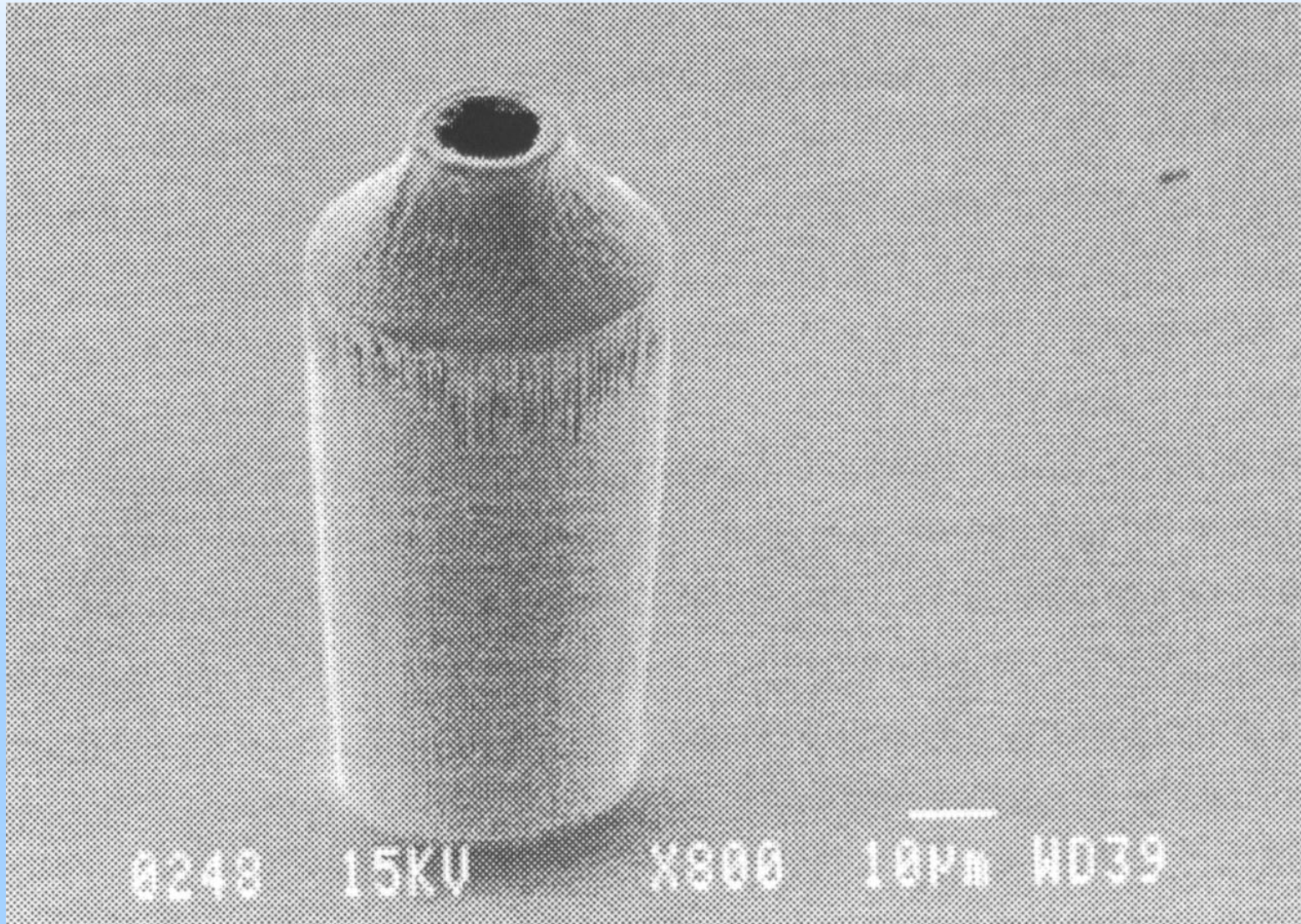
1 mm

x39
#7

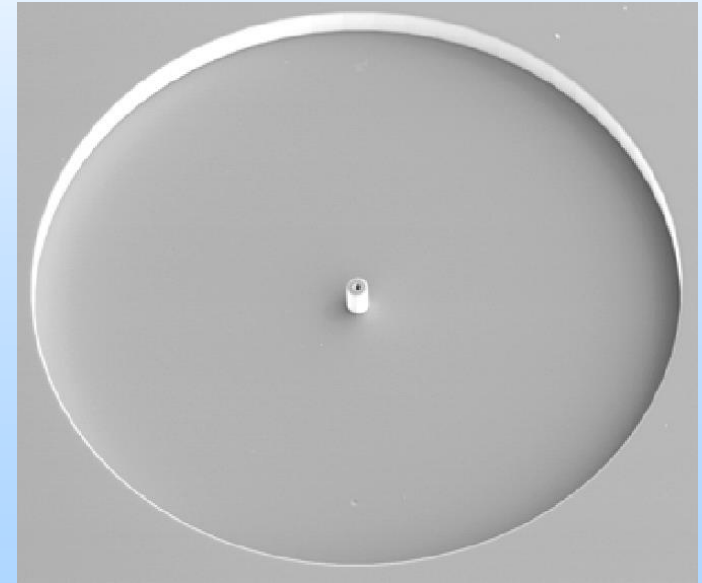
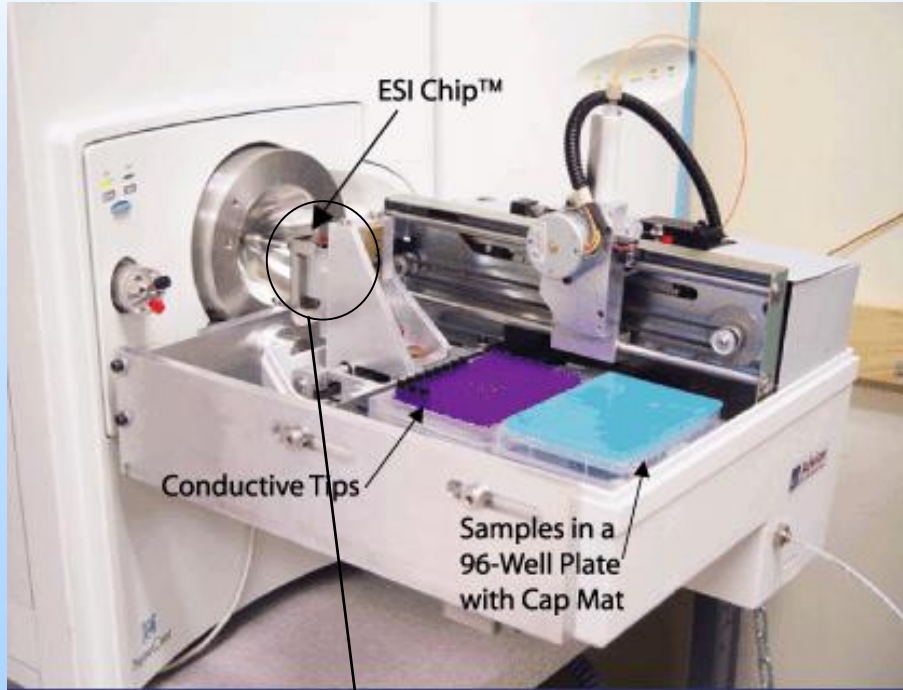
3.00kV
** IEMN **

4mm

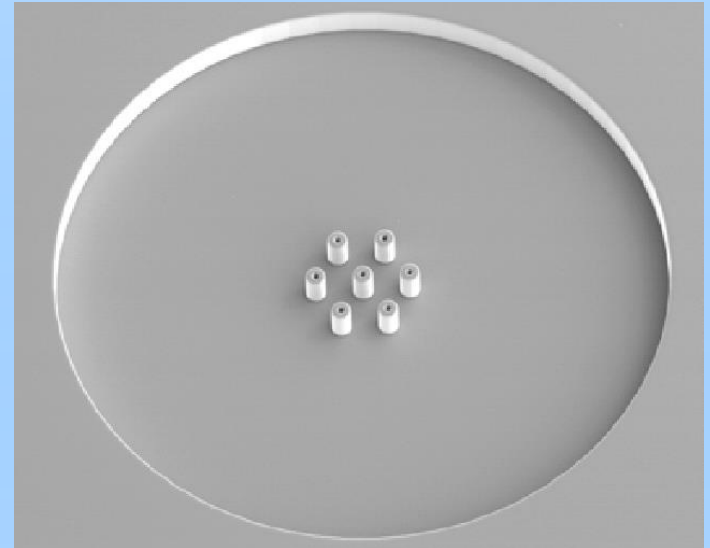
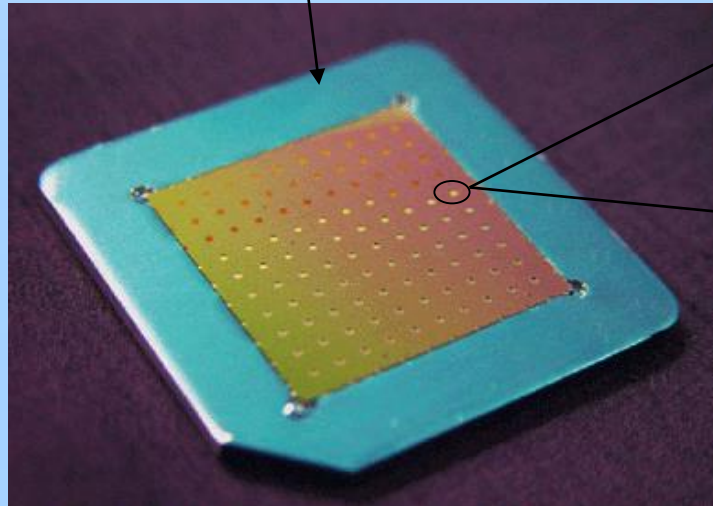
ESI tips produced by DRIE in silicon

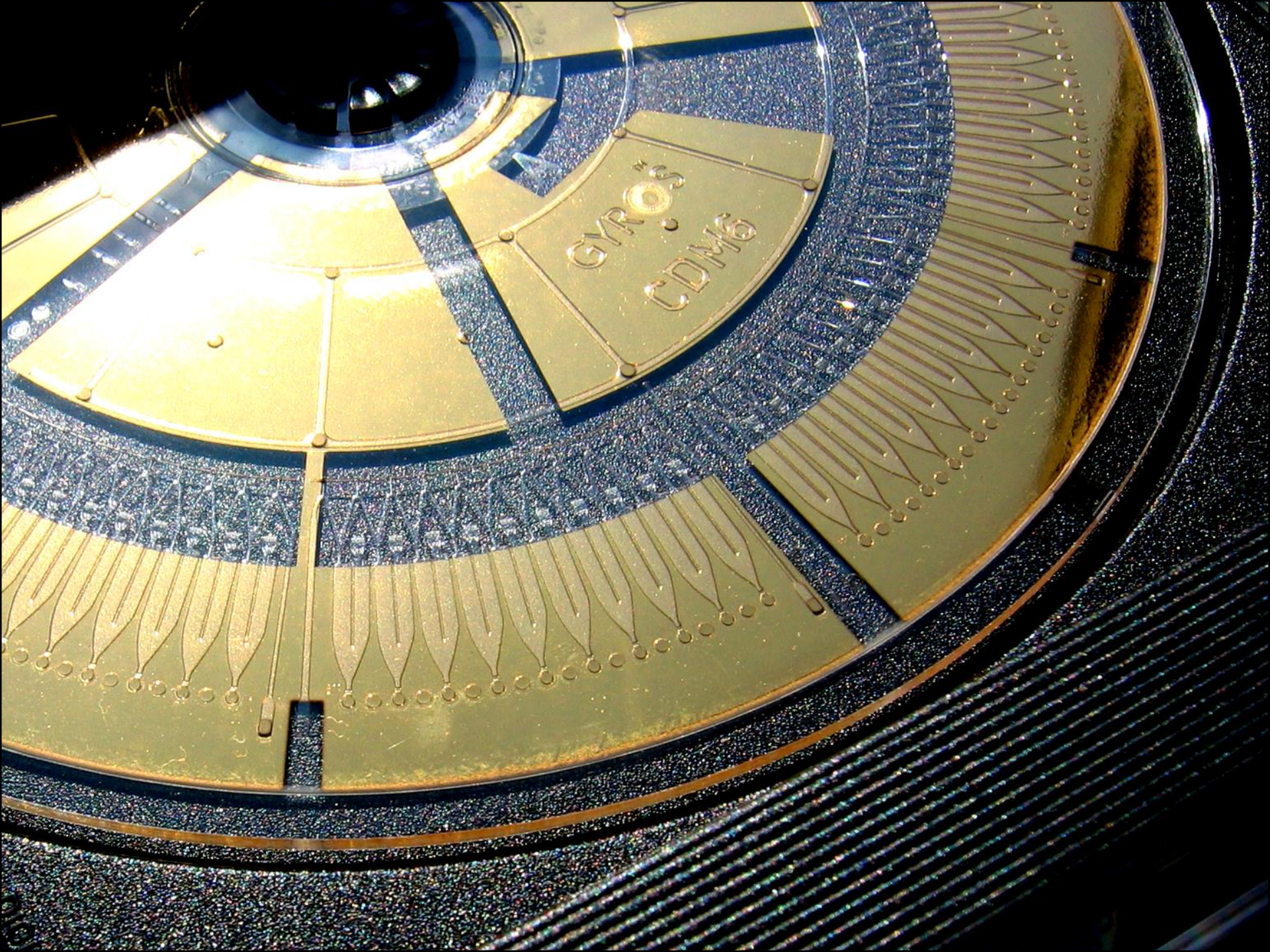


Infusion ESI Tip Array



www.advion.com

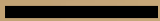




GYROS
CDM6

Integrated Au tips

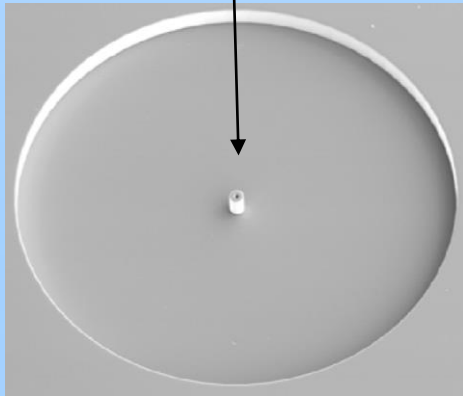
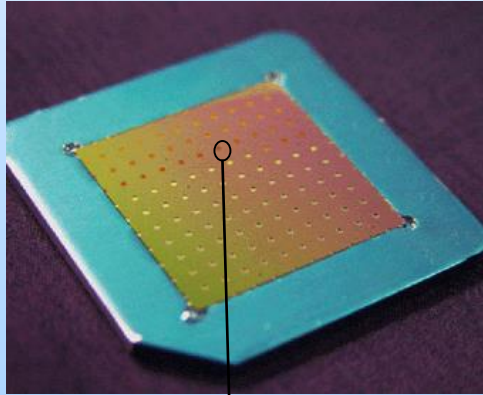
100 μm



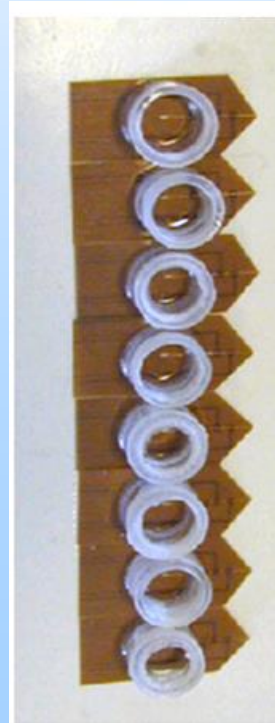
ESI tip fabrication

Plasma etched in polyimide

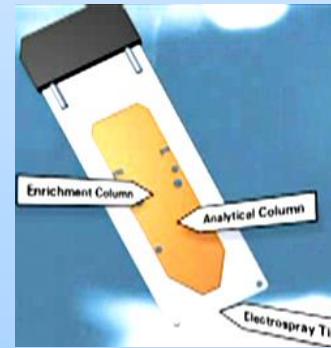
DRIE in silicone



www.advion.com



www.diagnoswiss.com



www.agilent.com

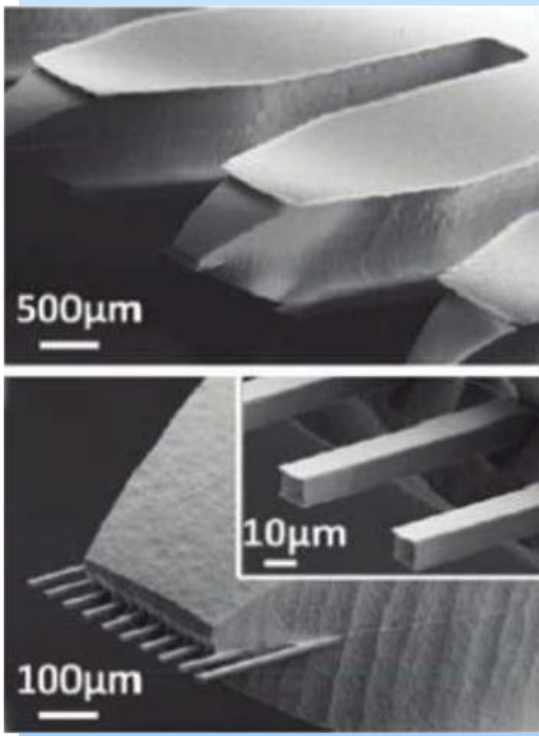
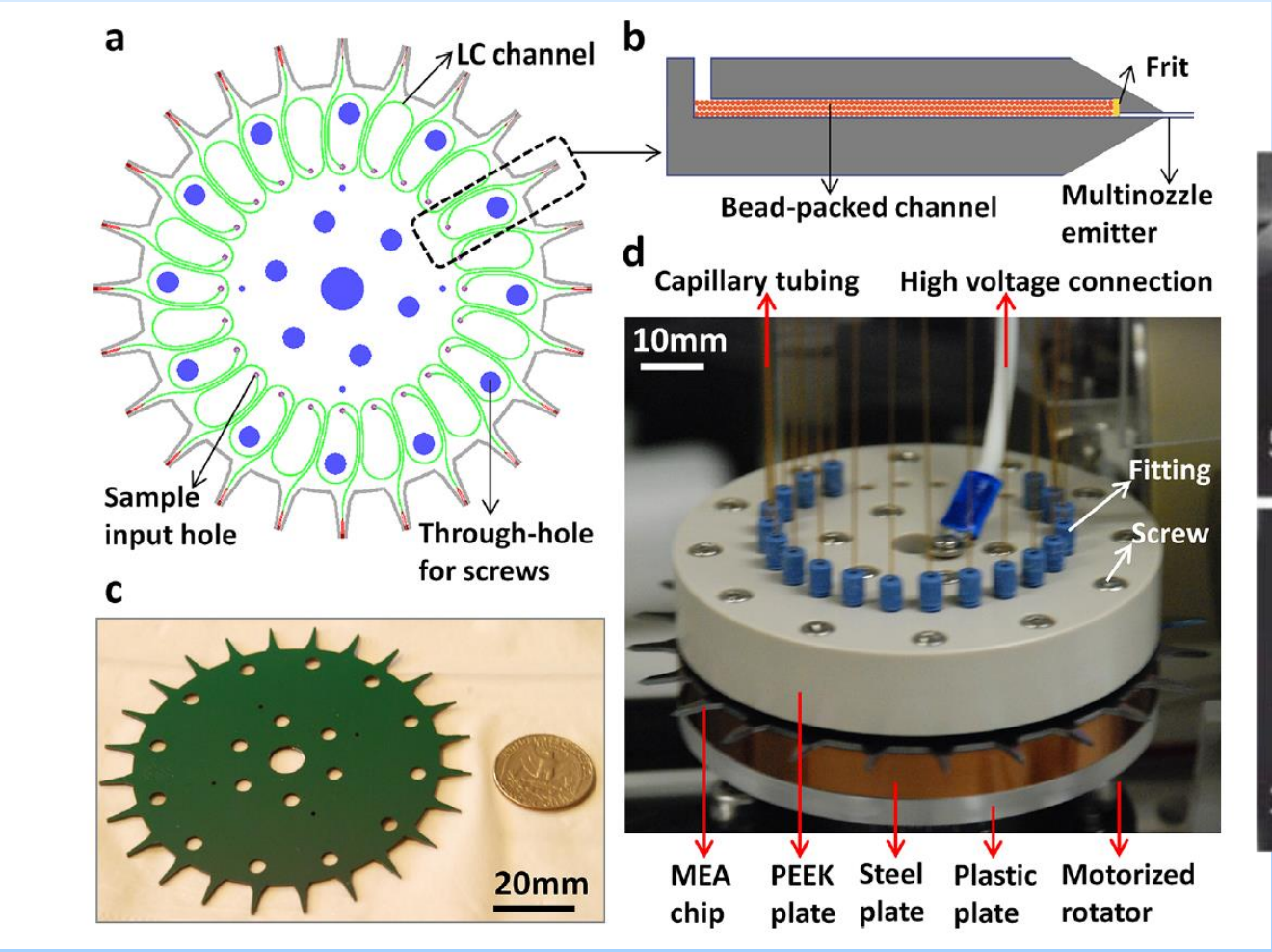
Injection molding in polypropylene



www.phoenix-st.com

Applications

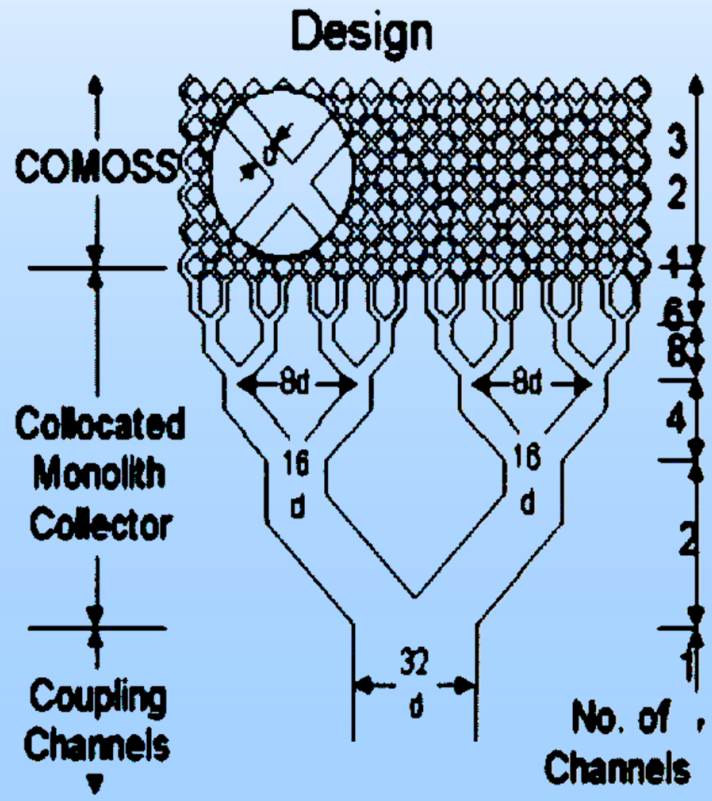
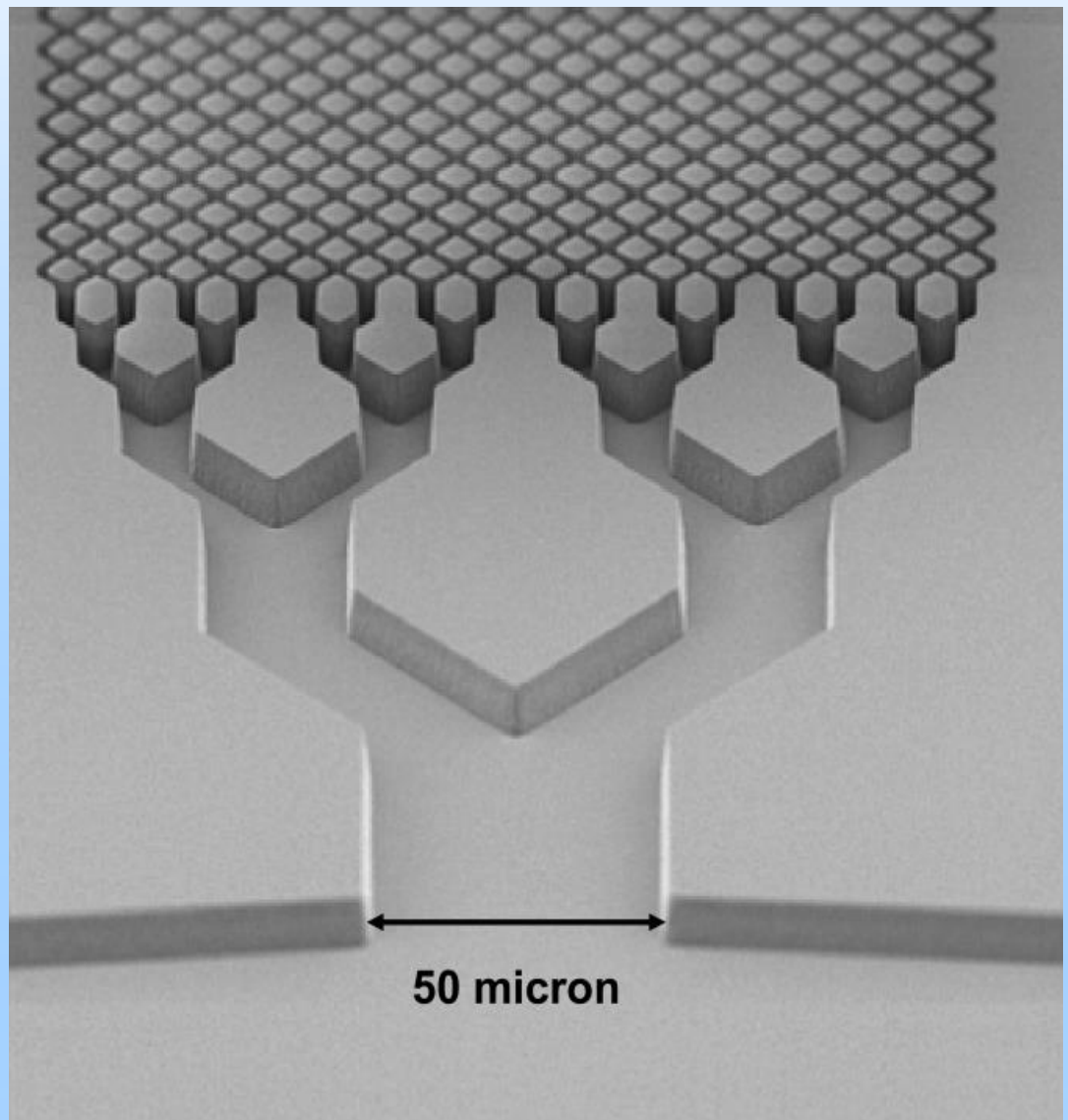
Multinozzle Emitter Array Chips for Small-Volume Proteomics



Mao, P; Gomez-Sjoberg, R; Wang, DJ. Anal. Chem. 2013, 85, 816-819.

Microfabricated Monolith Columns for Liquid Chromatography

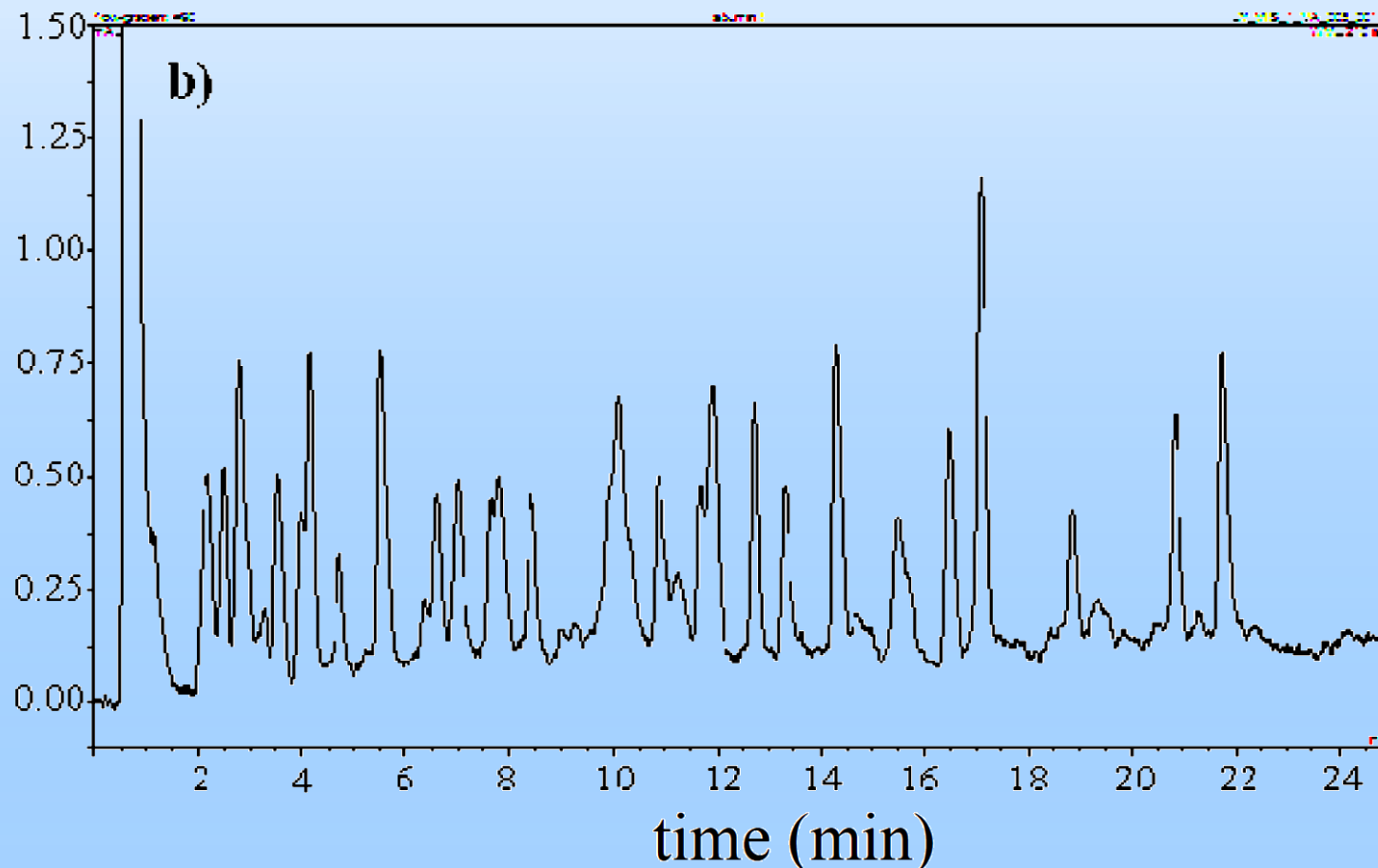
Sculpting Supports for Liquid Chromatology



Fred E. Regnier J. High Resol. Chromatogr. 2000, 23, (1) 19–26

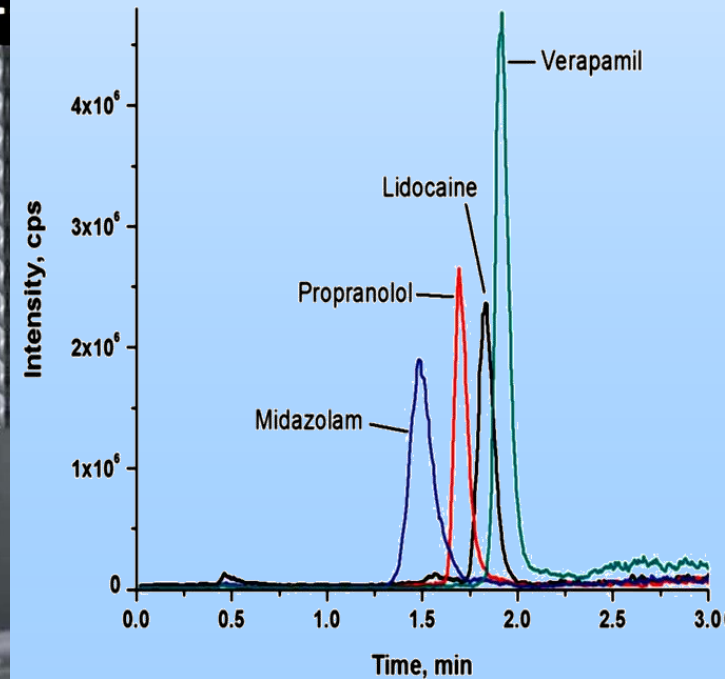
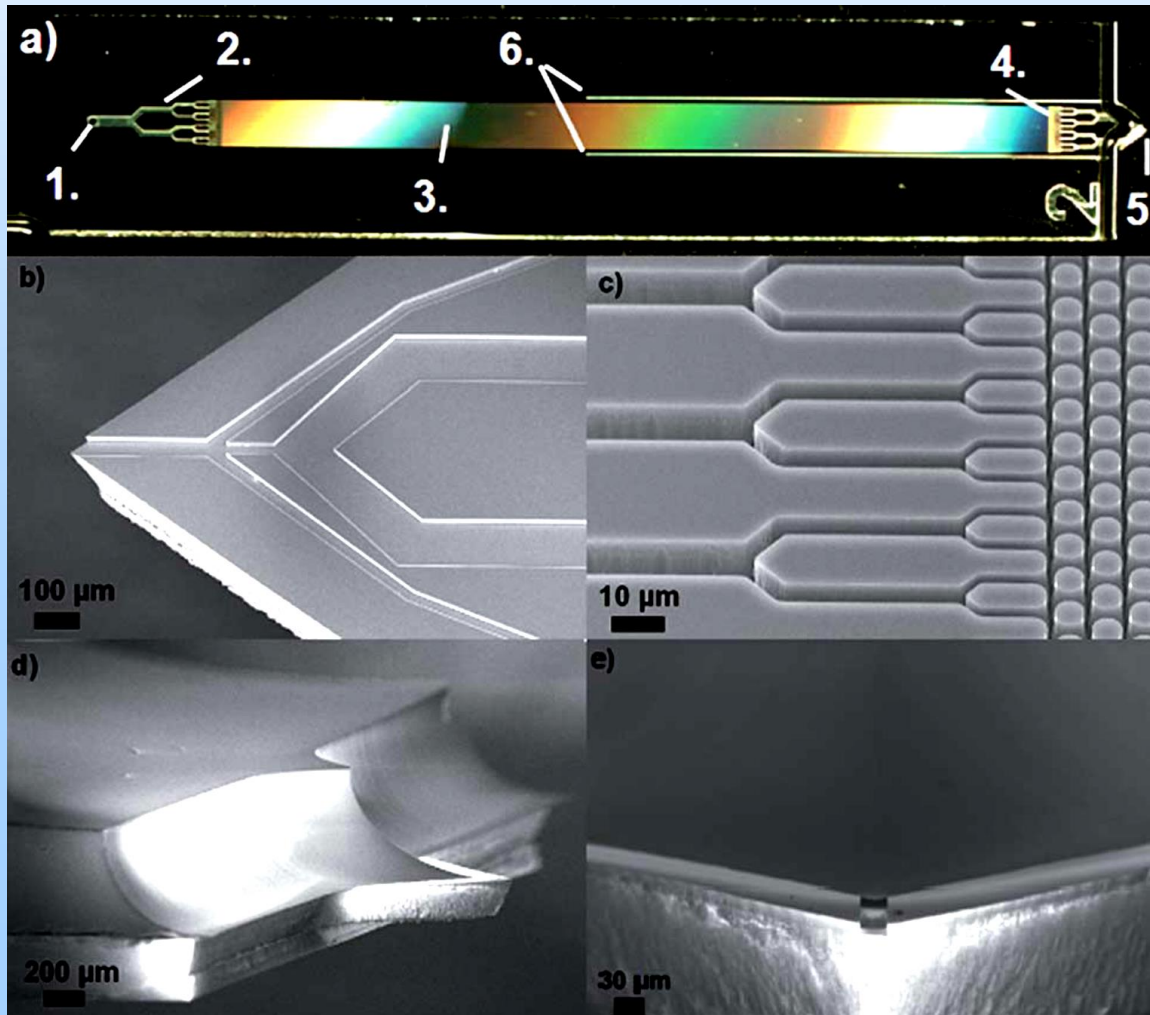
Gradient LC separation of albumin digest

(4 μ l/min, 1 mg/ml, UV detection)



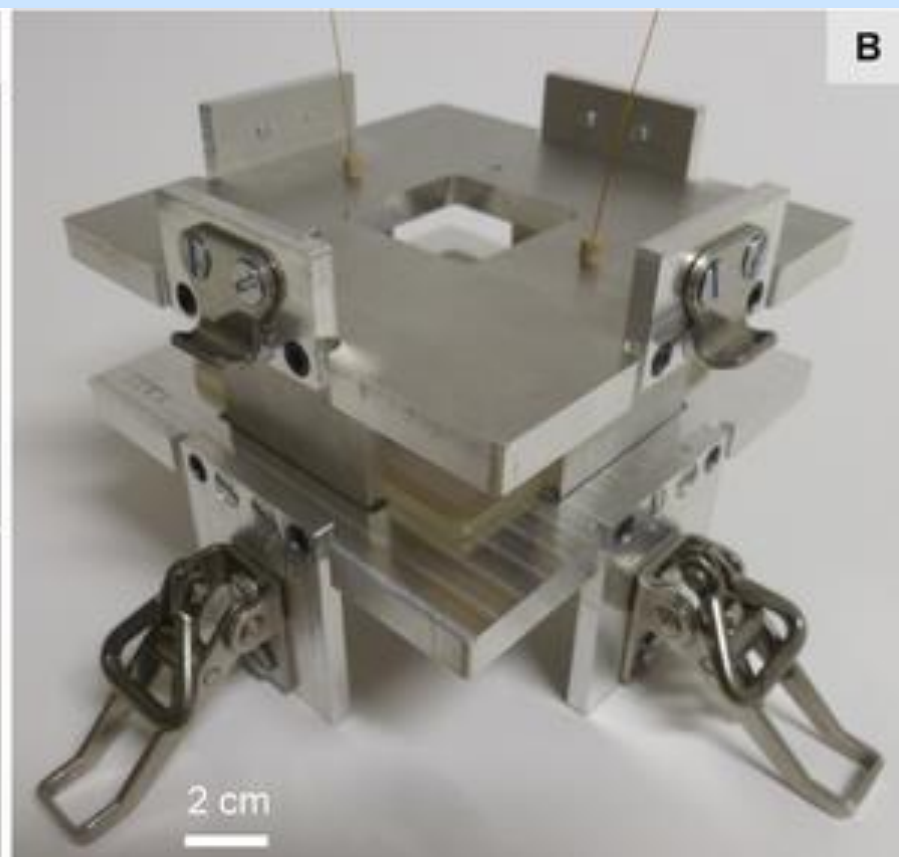
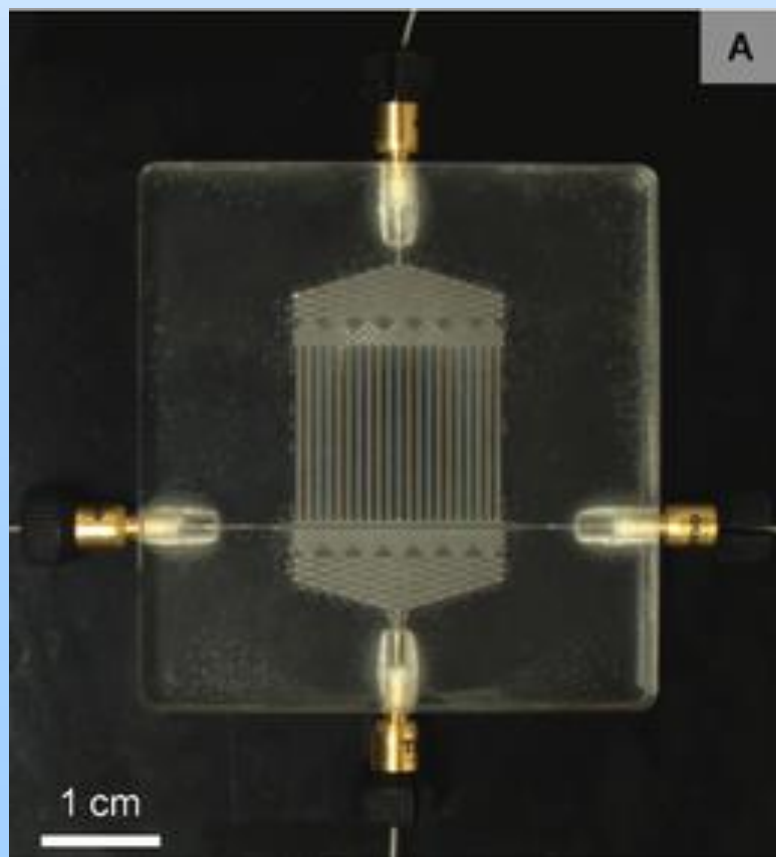
De Malsche W., De Bruyne S., Op de Beeck J., Eeltink S., Detobel F., Gardeniers H., Desmet G.
Journal of Separation Science 2012, 35, 2010-2017

A microfabricated micropillar liquid chromatographic chip Monolithically integrated with an electrospray ionization tip

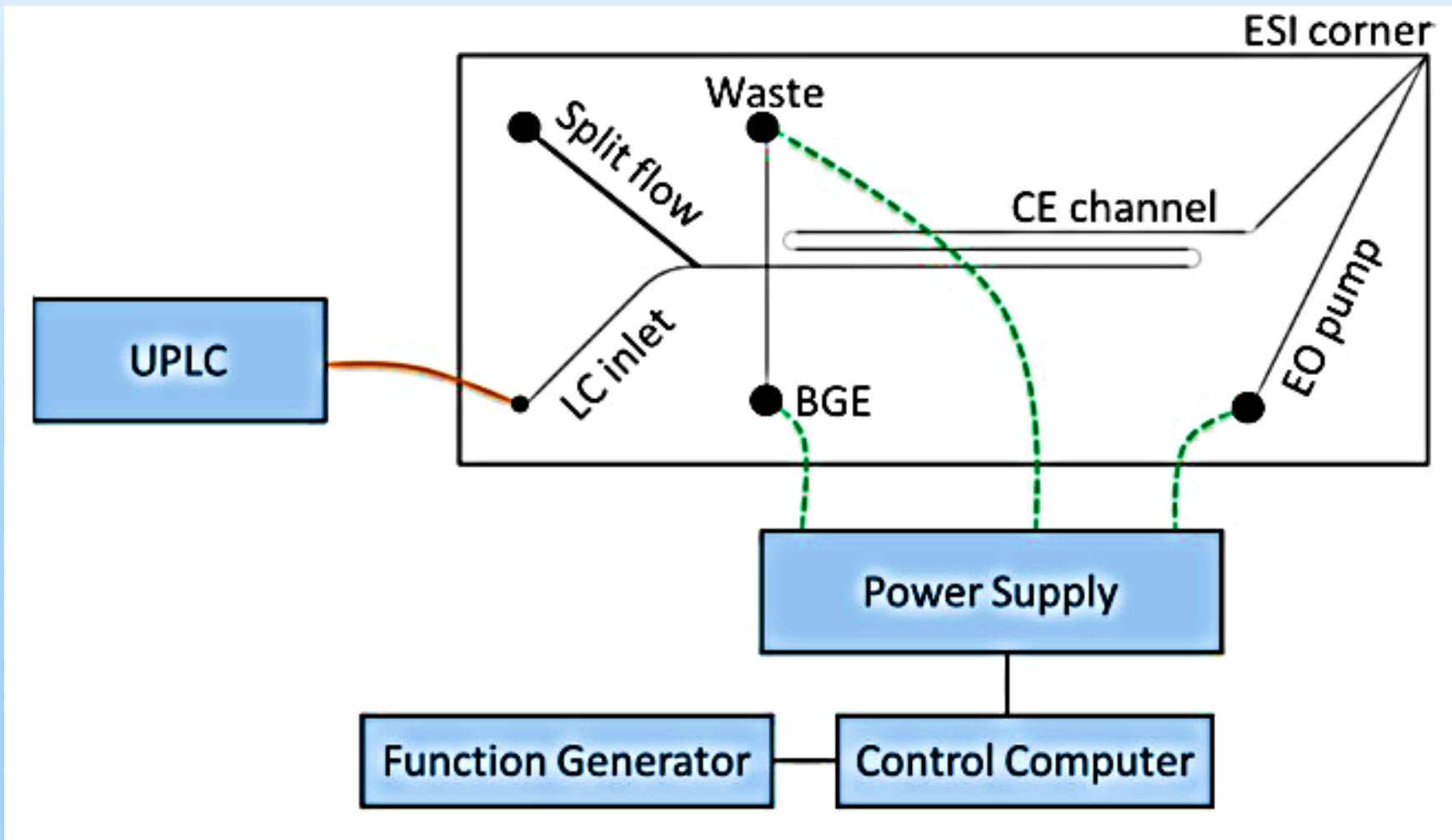


Lauri Sainiemi, Teemu Nissilä, Risto Kostianen, Sami Franssila and Raimo A. Ketola
Lab Chip, 2012, 12, 325

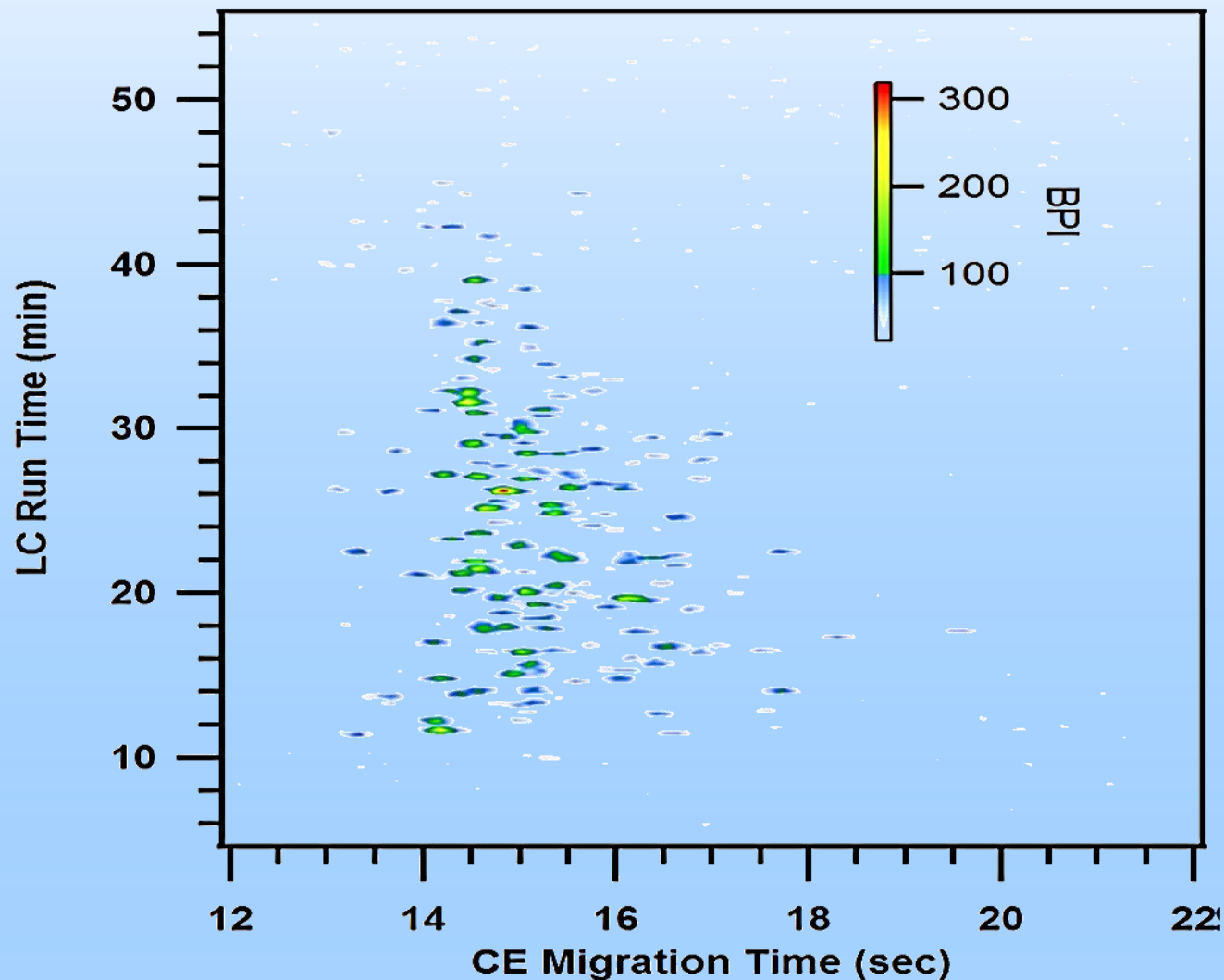
Design of a microfluidic device for comprehensive spatial two-dimensional liquid chromatography



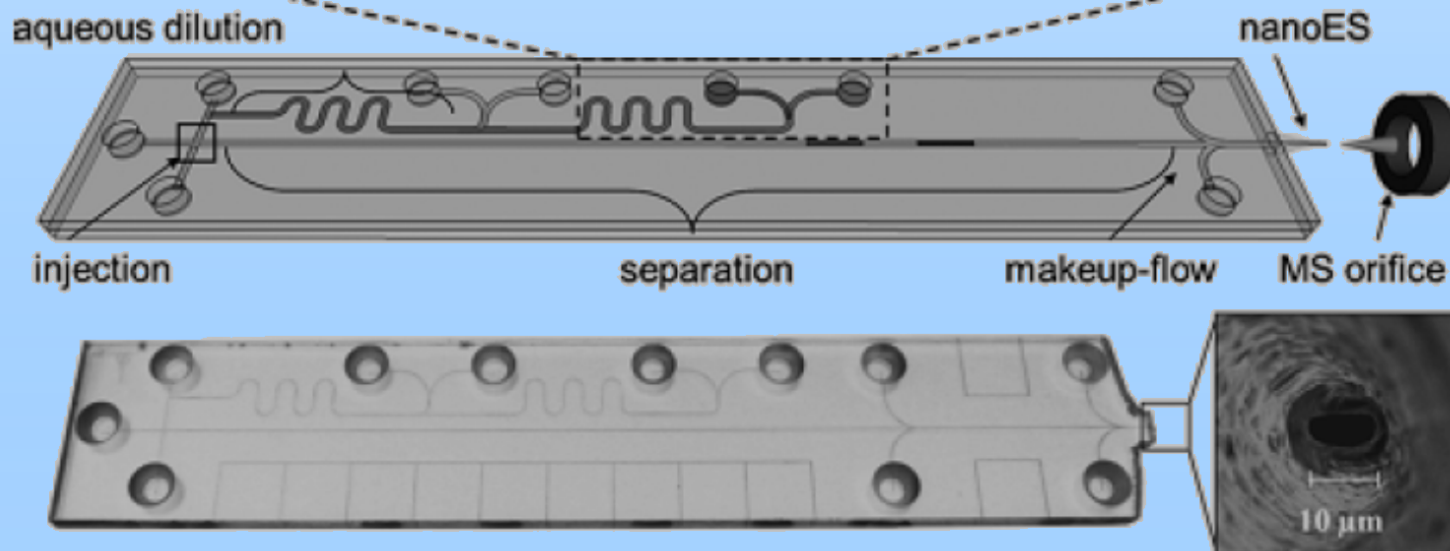
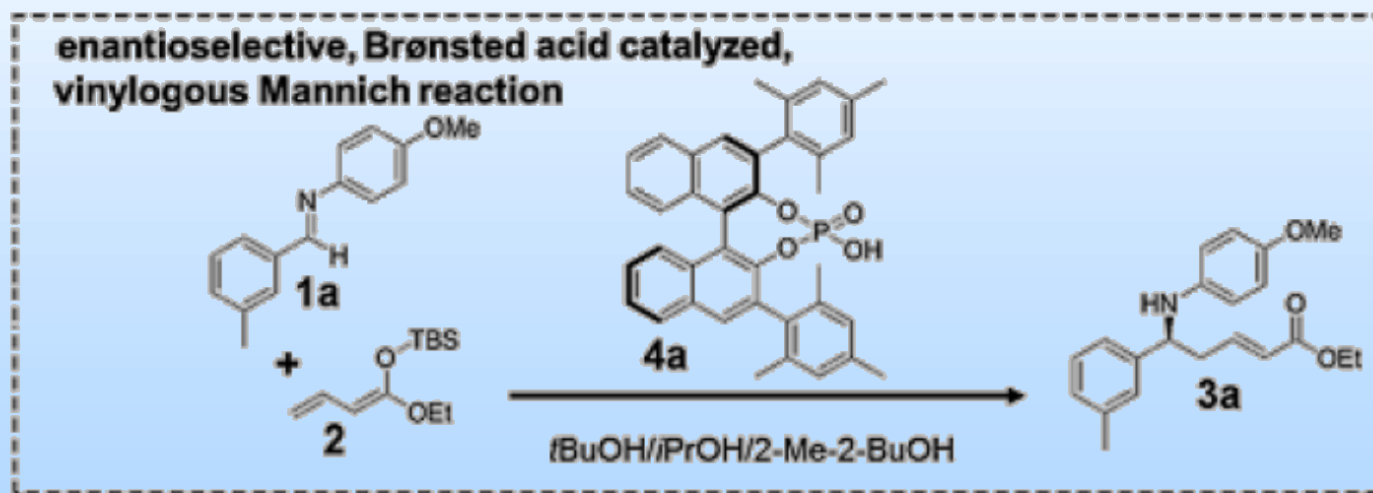
Hybrid Capillary/Microfluidic System for Comprehensive Online Liquid Chromatography-Capillary Electrophoresis-ESI-MS



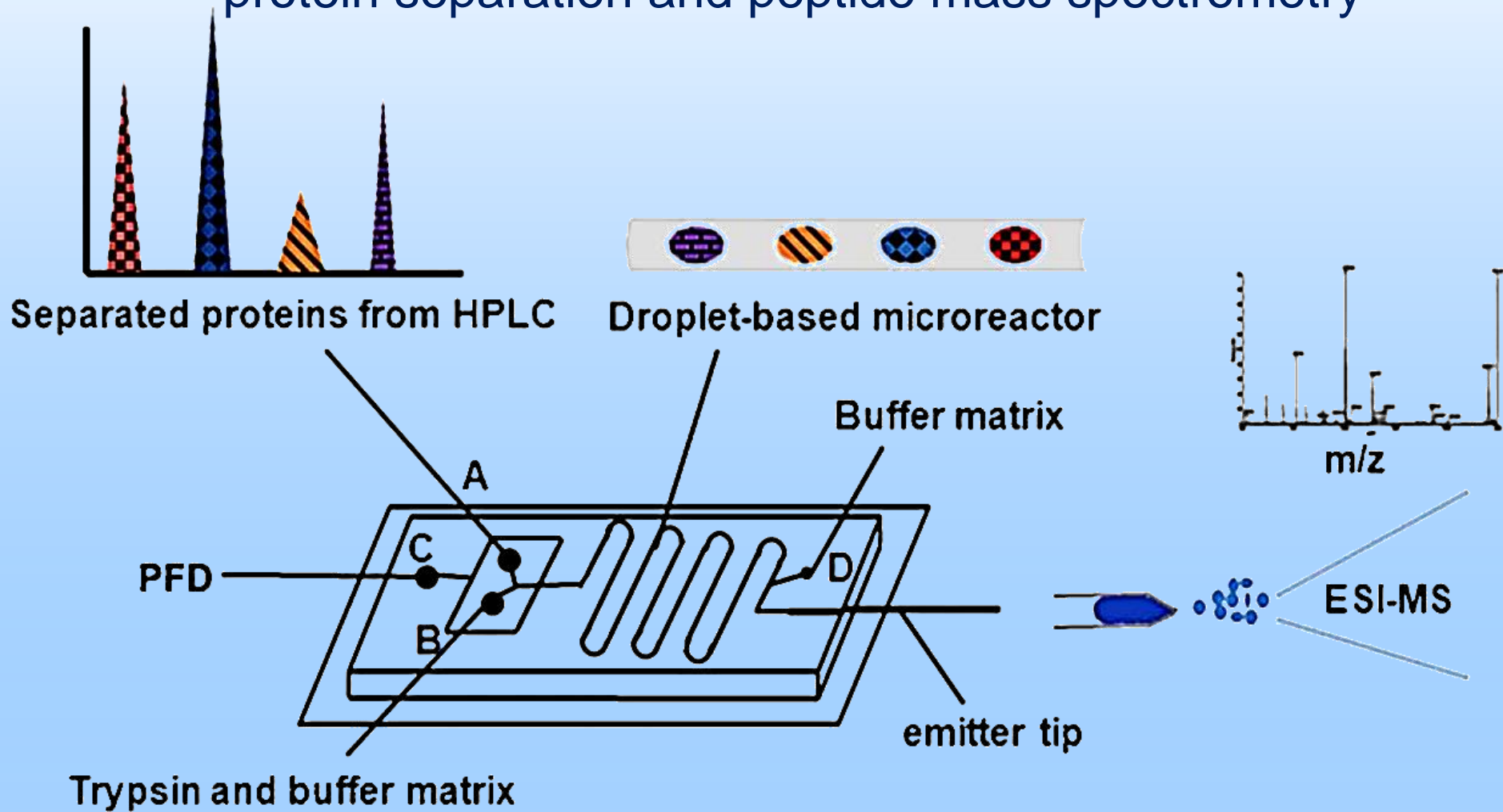
Hybrid Capillary/Microfluidic System for Comprehensive Online Liquid Chromatography-Capillary Electrophoresis-ESI-MS



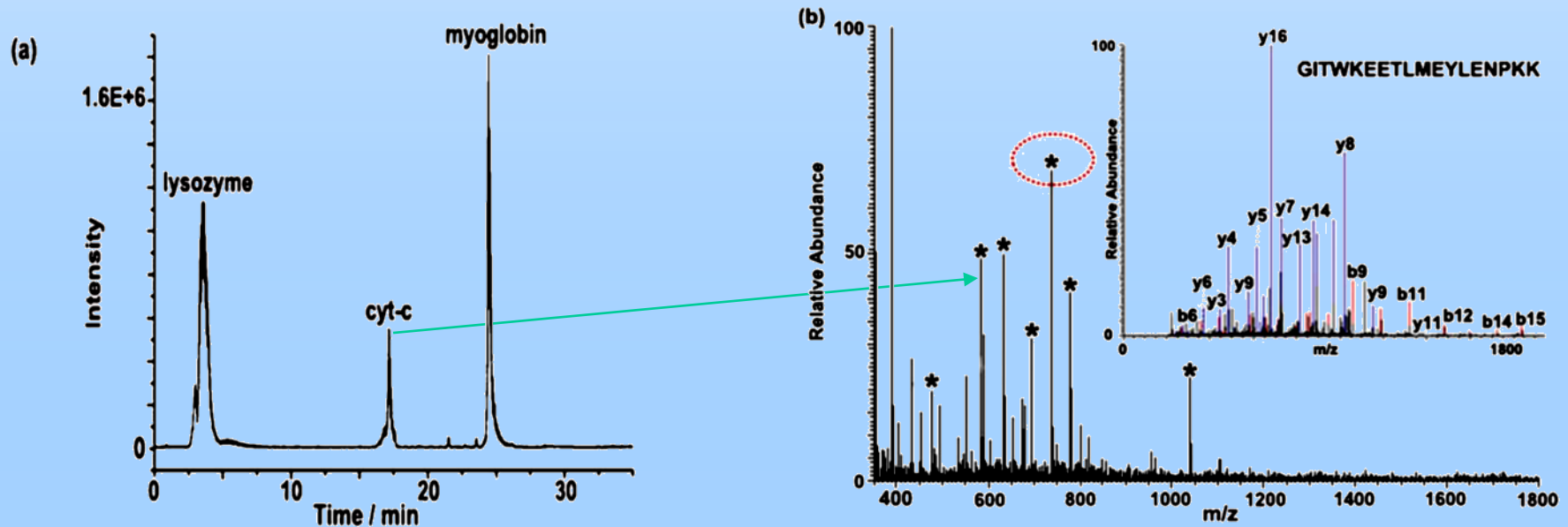
Asymmetric Organocatalysis and Analysis on a Nanospray Chip



Proteolysis in microfluidic droplets: an approach to interface protein separation and peptide mass spectrometry

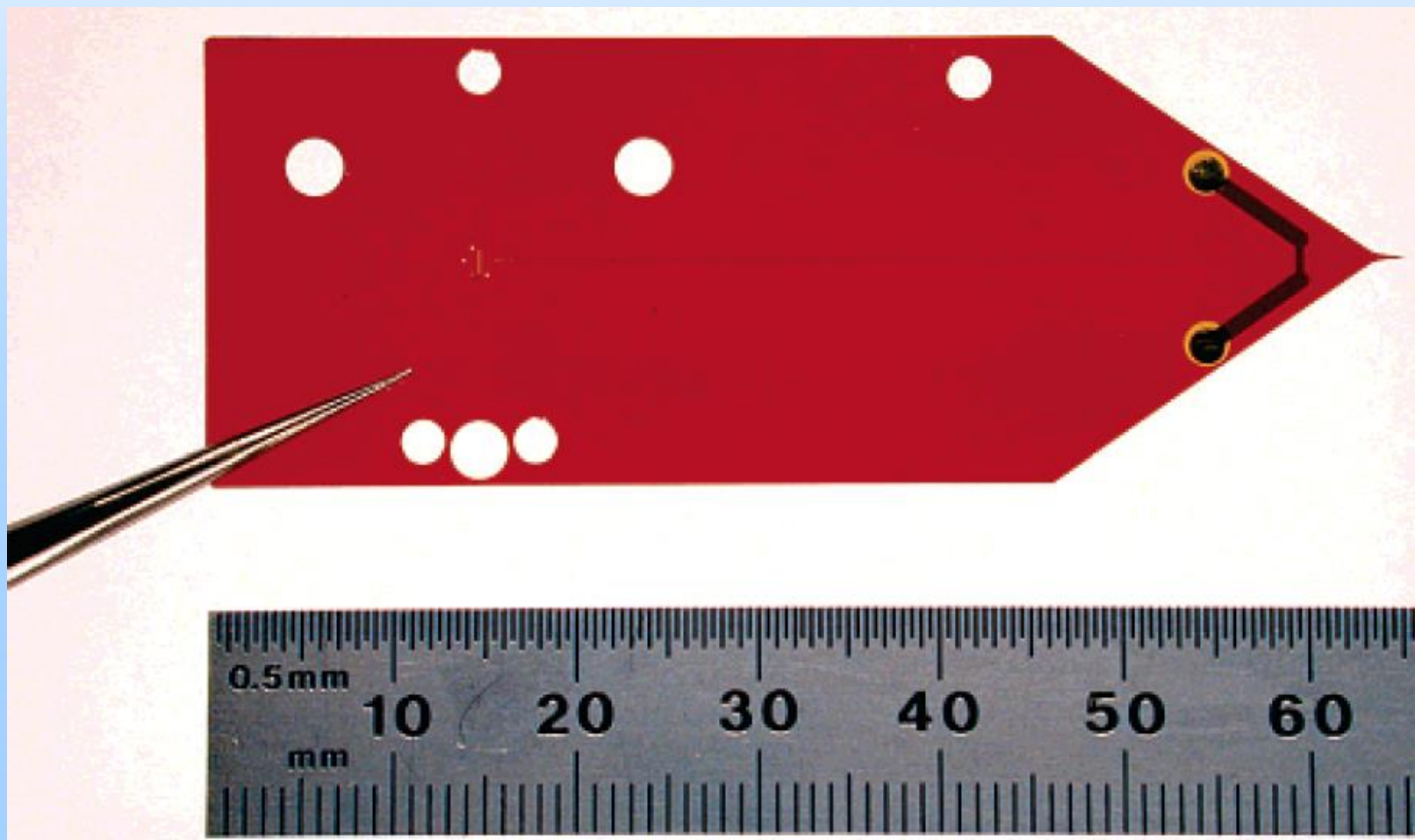


Proteolysis in microfluidic droplets: an approach to interface protein separation and peptide mass spectrometry

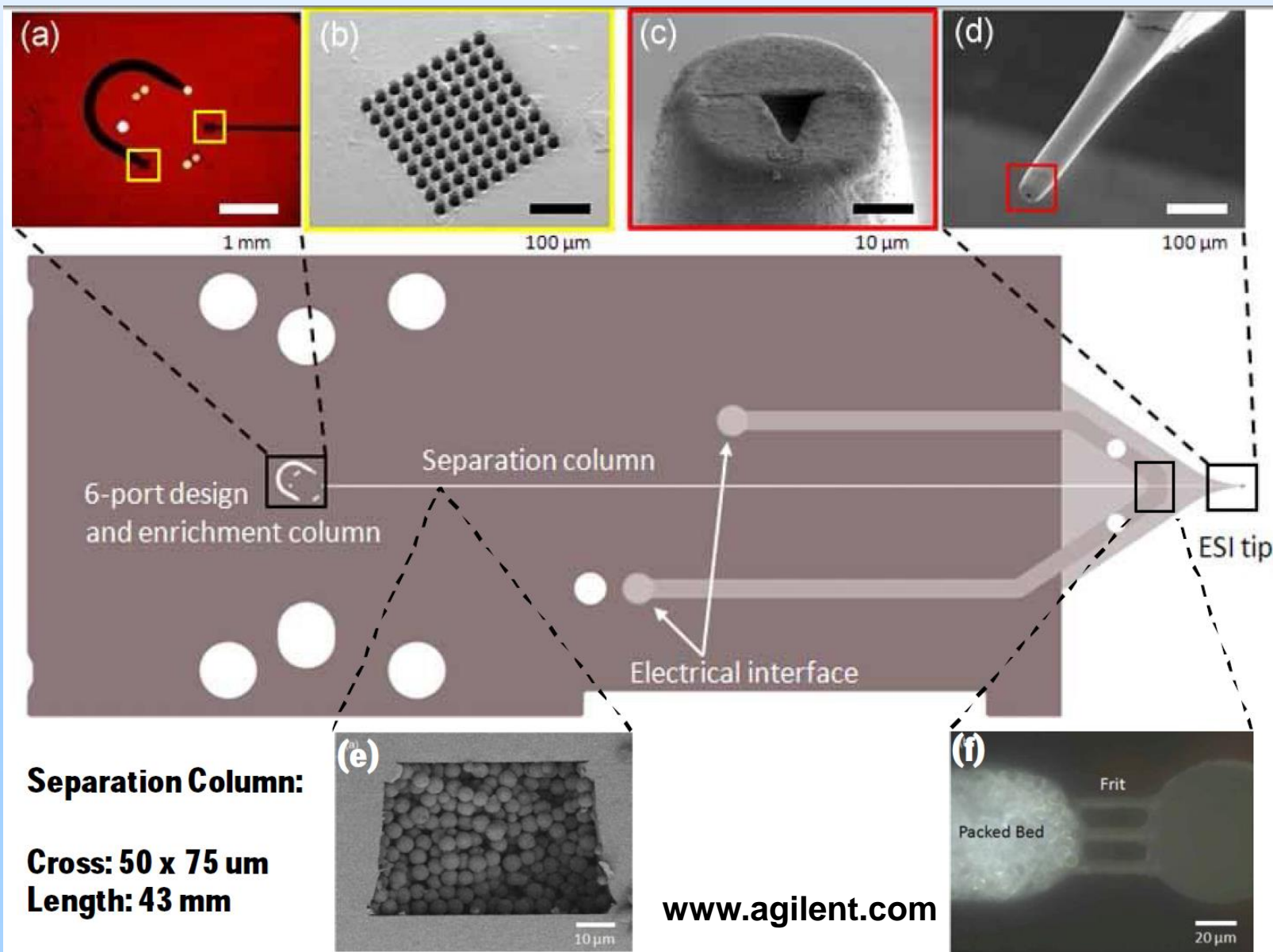


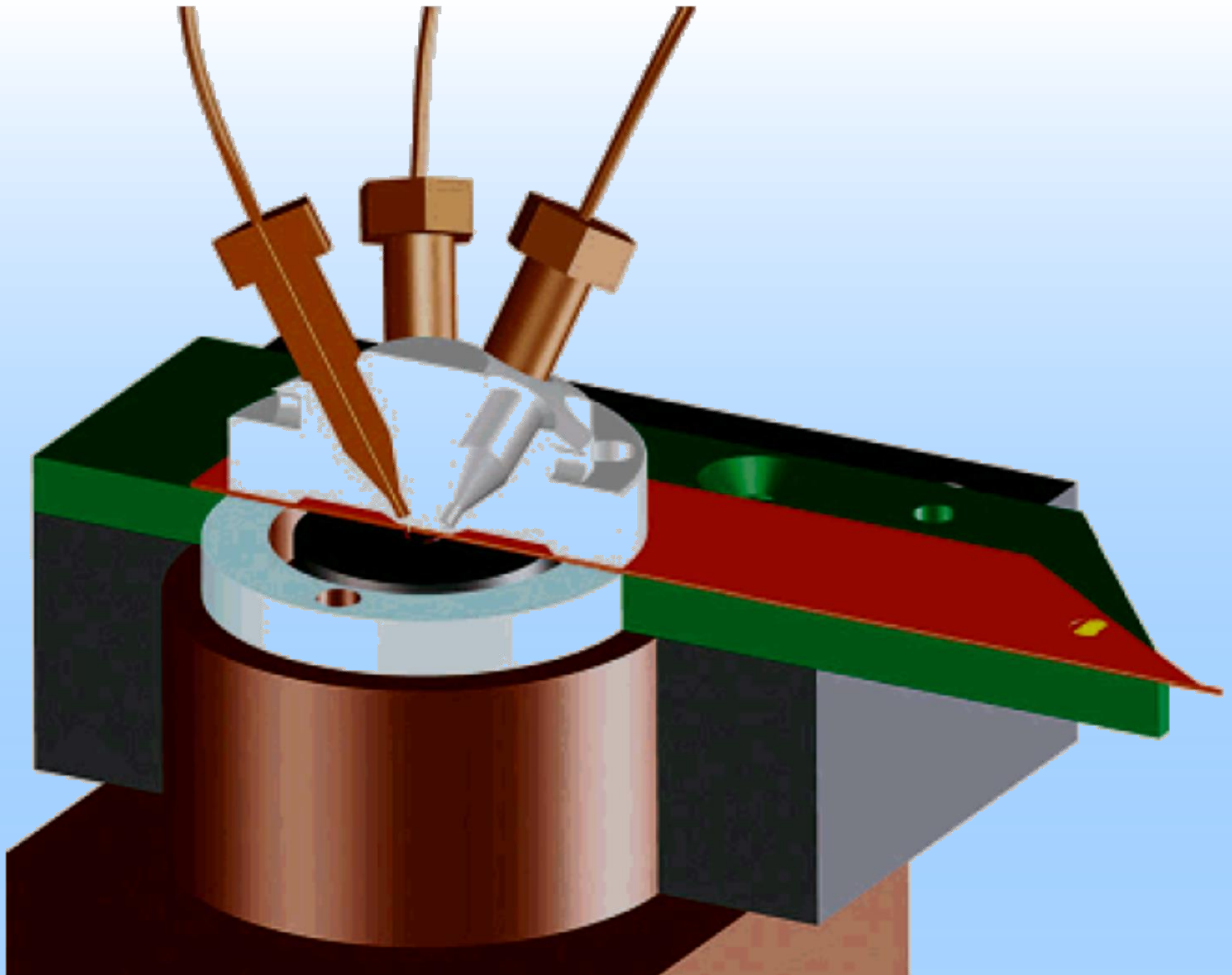
Commercialization

Microfluidic Chip for Peptide Analysis with an Integrated HPLC Column, Sample Enrichment Column, and Nanoelectrospray Tip



Polyimide HPLC-chip, integrating an enrichment column, frits, a laser ablated ESI tip and trapazoidal separation column



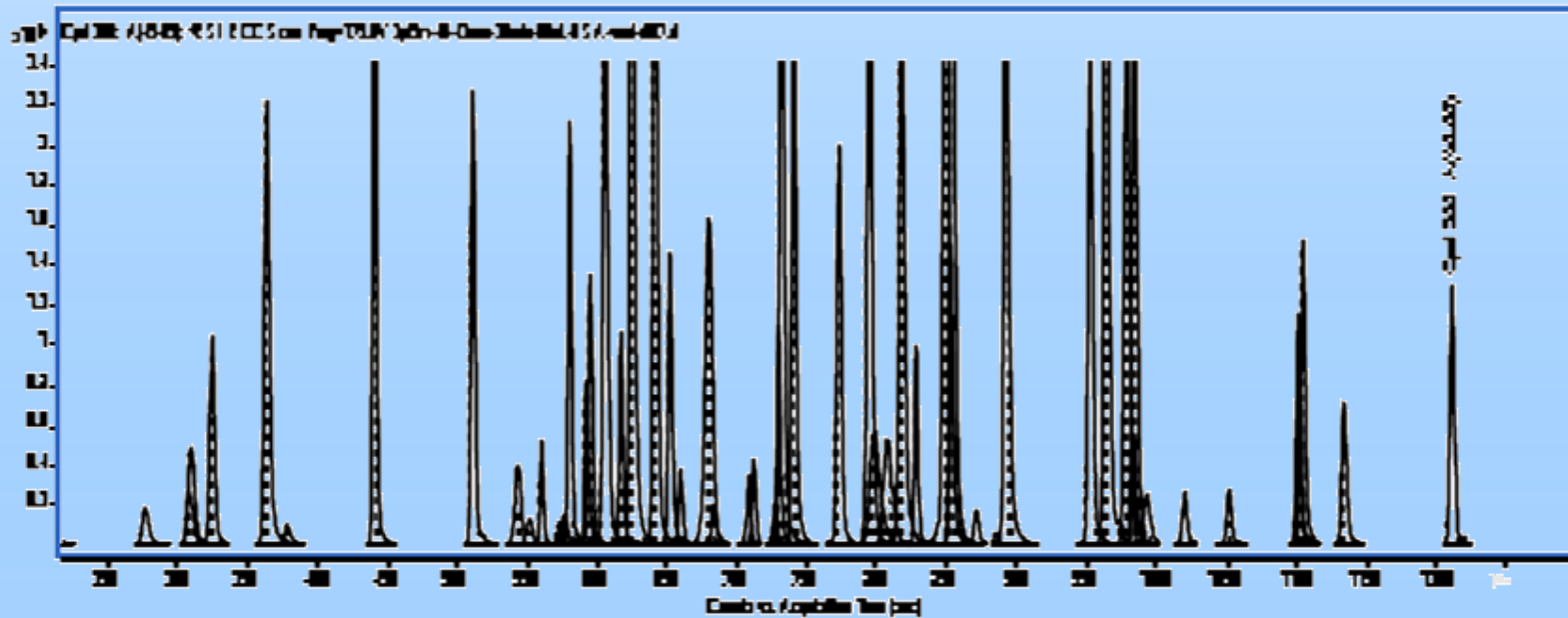


Segmented column HPLC/chip



Three LC columns – length 130 mm
Each segment individually packed.

Multi-segment three chip stack in enclosure.



BSA digest separated with a 30min gradient on a 2 column segmented chip, packed with 3.5 μ m particles

TRIZAIC nanoTile - Waters

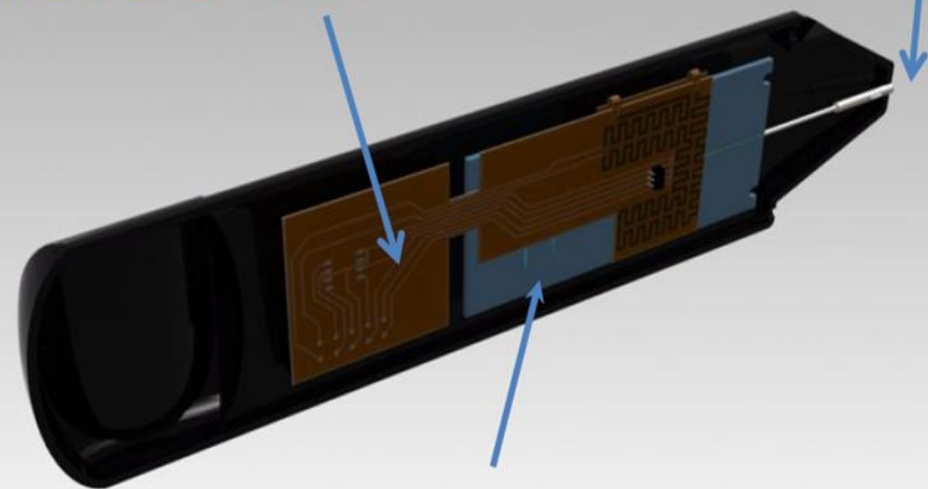
- UPLC Performance
- All fluidic connections are pre-made & factory tested
- Integrated ESI Emitter
- Low System Volumes
- Decreased Band Broadening
- Higher Sensitivity
- Incorporates:
 - Heater & Sensor
 - EPROM
- Increased Reproducibility

1.7 μm BEH

TRIZAIC™
UPLC SYSTEM

Built-in Heater,
Sensors, EPROM

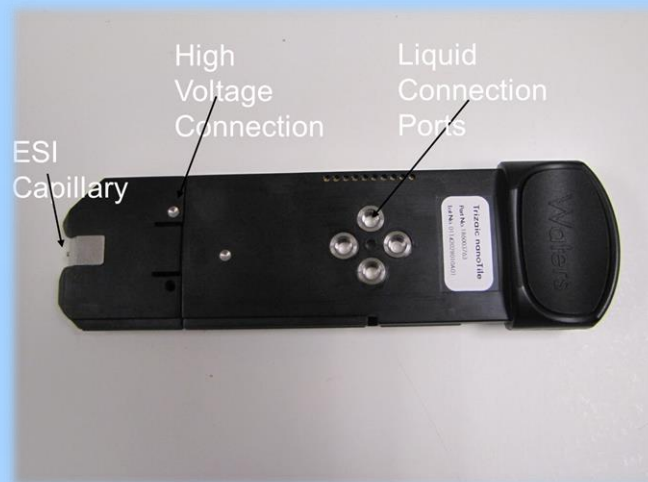
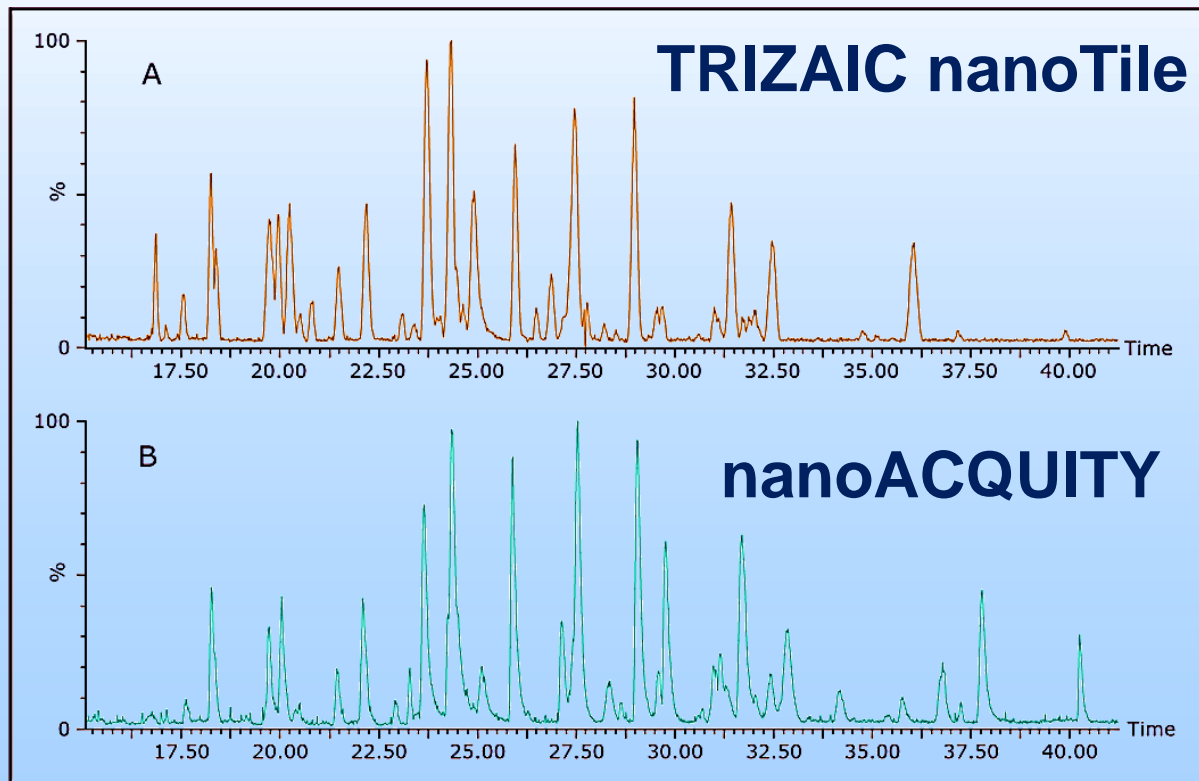
ESI Emitter



UPLC 'Column'

Enolase digest

70 fmol, 2 μ m particles





- 150 μm ID Channel
- Sub-2- μm UPLC® Chemistries
- 10,000 psi Pressure Capability

- 1–7 pH Range
- Plug and Play Design
- Built-in eCord™

- Built-in Emitter
- Embedded Column Heater

Green tape

Al_2O_3 – MgO – SiO_2 glass particles mixed with organic binders and solvents to form glass ceramic

Product Description

951 Green Tape is a low-temperature cofired ceramic tape.

The 951 system comprises a complete cofireable family of Au and Ag metallizations, buried passives, and encapsulants.

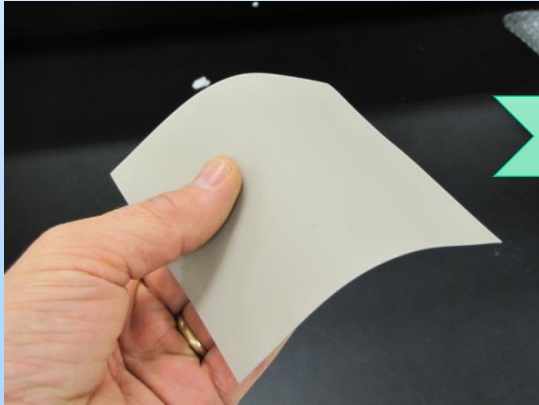
951 is available in multiple thicknesses for use as an insulating layer in:

- Multichip modules
- Single chip packages
- Ceramic printed wiring boards
- RF modules

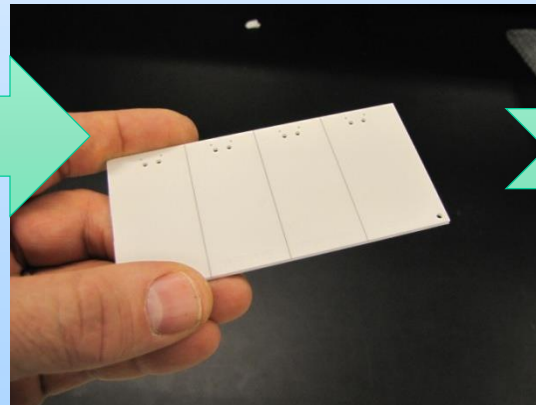
<http://www.dupont.com/mcm>

Ceramic Microfluidic Fabrication

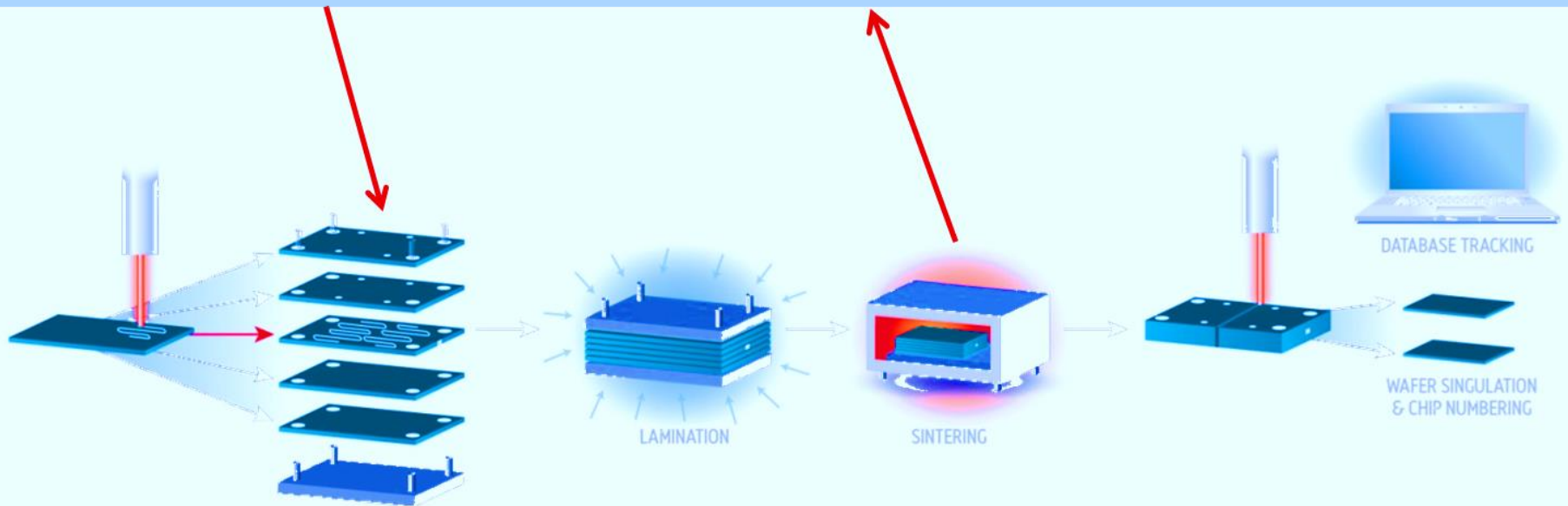
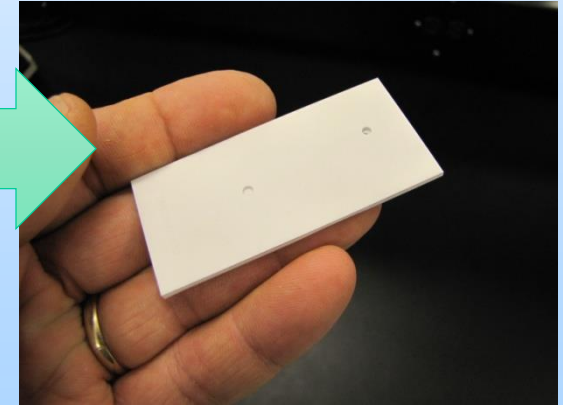
Cut Ceramic Material



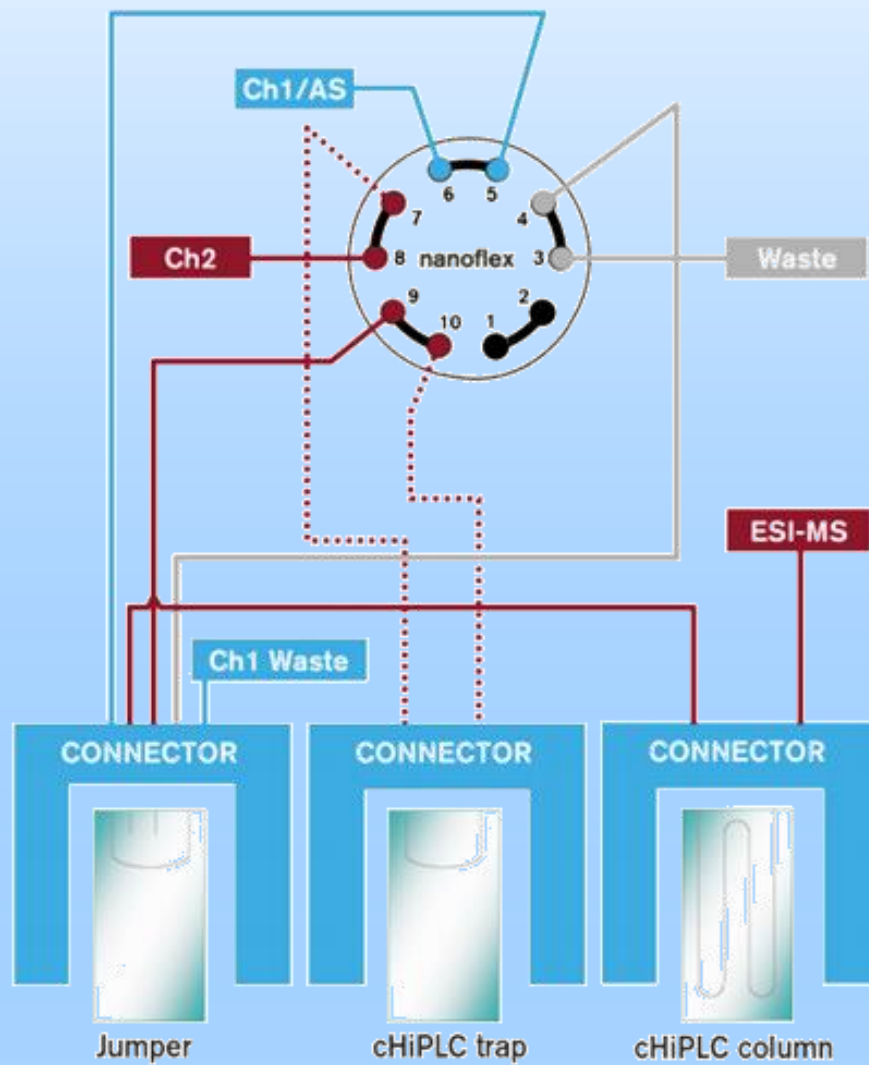
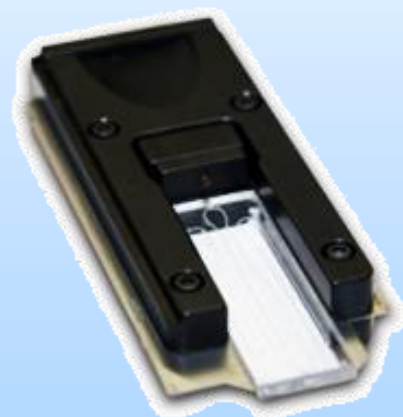
Fired Wafer



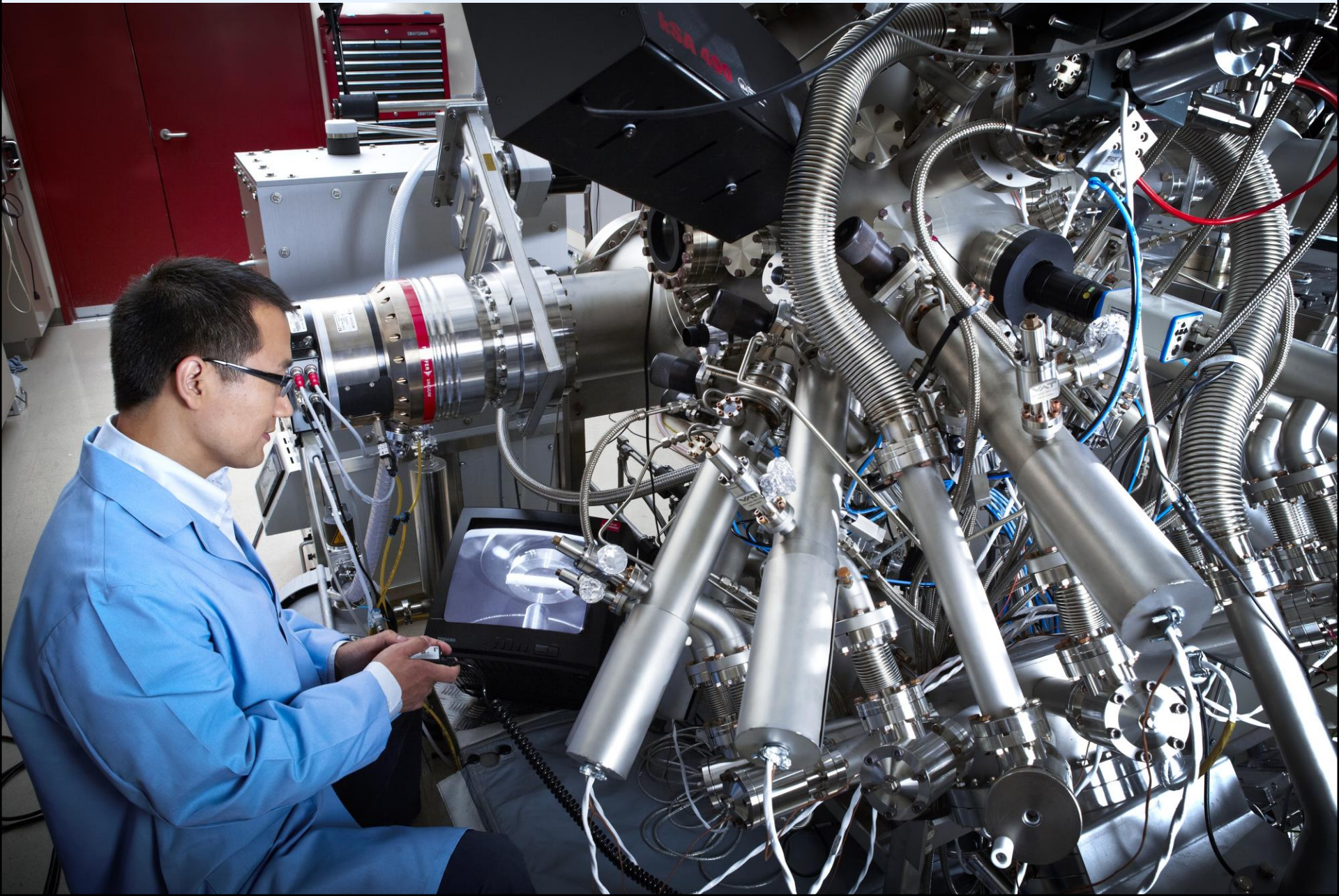
Final Diced Part



Packed glass LC chip



Miniaturized (microfabricated) mass spectrometers?

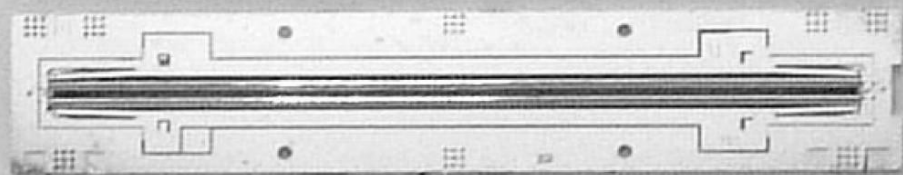


Applications of Miniaturized MS Instruments

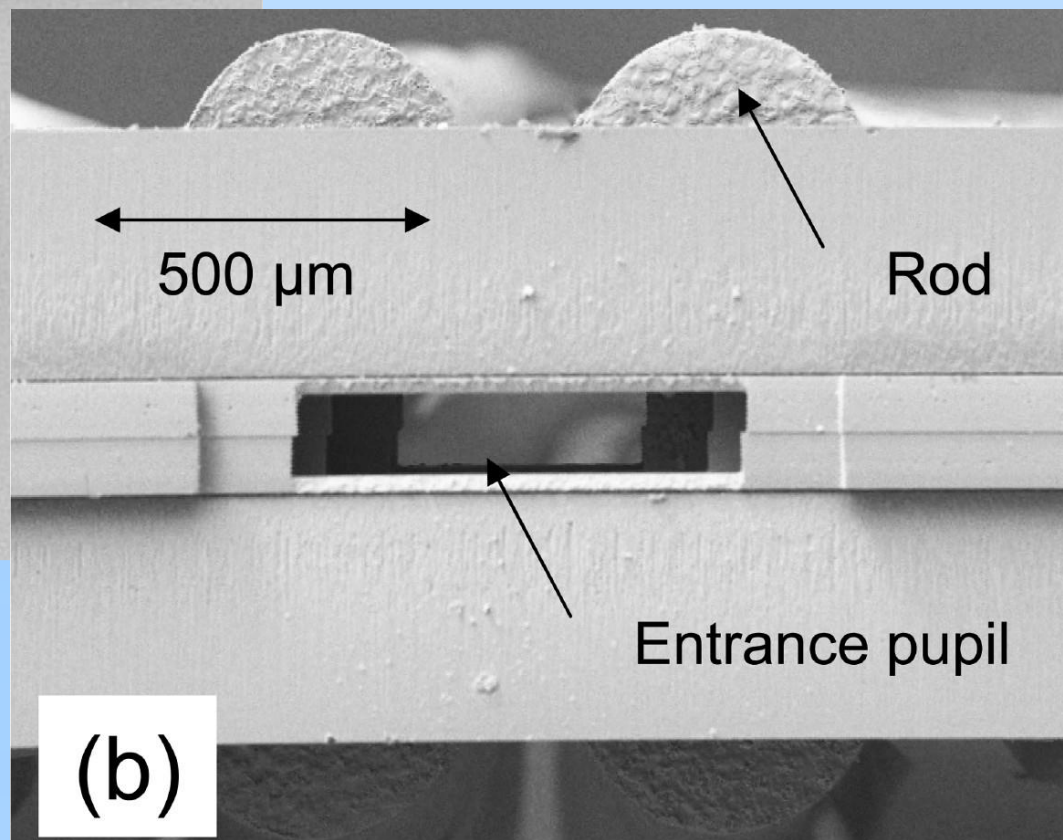
- trace explosive detection and airport security
- space exploration
- environmental monitoring
- point-of-care medical applications



Miniature Mass Spectrometer Systems based on a Microengineered Quadrupole Filter

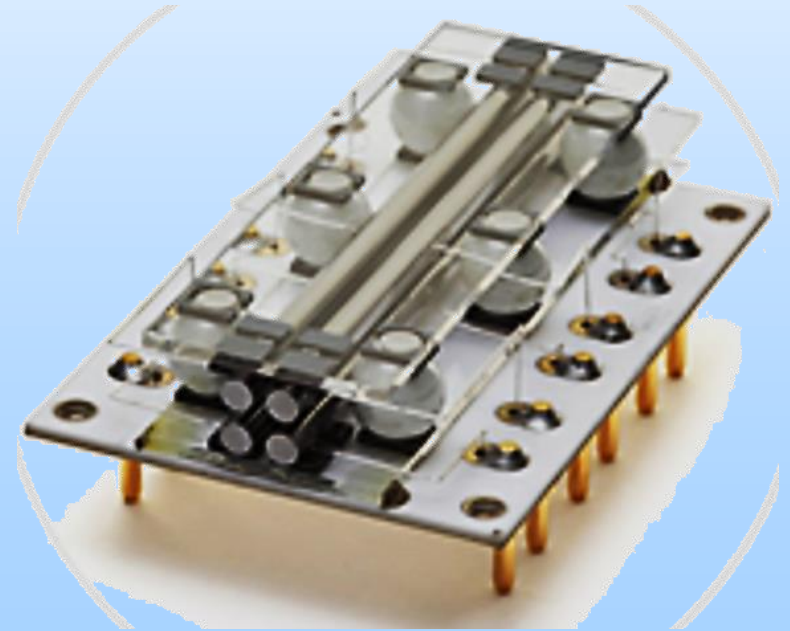


(a)



(b)

A. Malcolm, S. Wright, R. R. A. Syms,
N. Dash, M.-A. Schwab, A. Finlay
Anal. Chem. **2010**, *82*, 1751–1758



Mass Analyzer ionchip® quadrupole mass spectrometer

Mass Range m/z 50-800 with ionchip®150

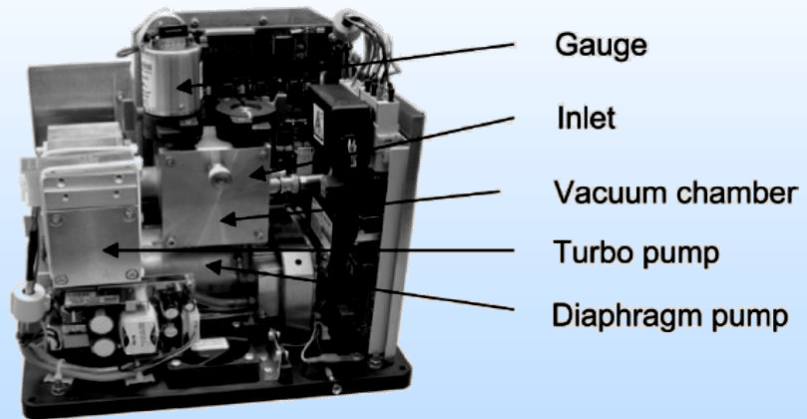
Mass Accuracy $\pm m/z$ 0.3 in full scan

Mass Resolution m/z 0.7 ± 0.1 FWHM

Sensitivity 10pg of reserpine in SIM mode S/N ratio of 10:1 (RMS)



27 cm



Gauge

Inlet

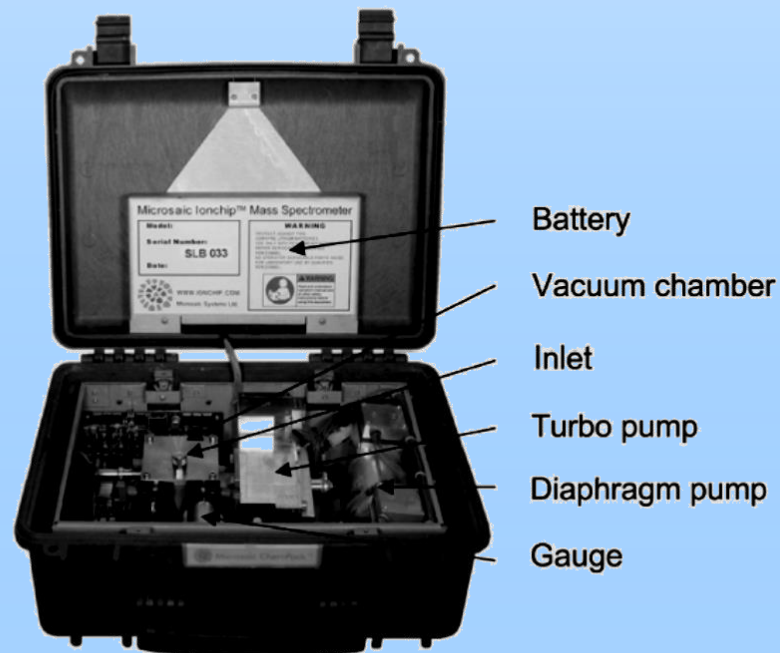
Vacuum chamber

Turbo pump

Diaphragm pump



38 cm



Battery

Vacuum chamber

Inlet

Turbo pump

Diaphragm pump

Gauge

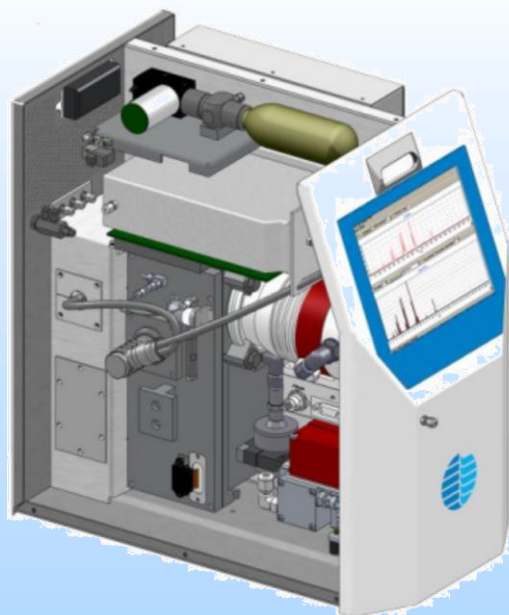


Microsaic Systems

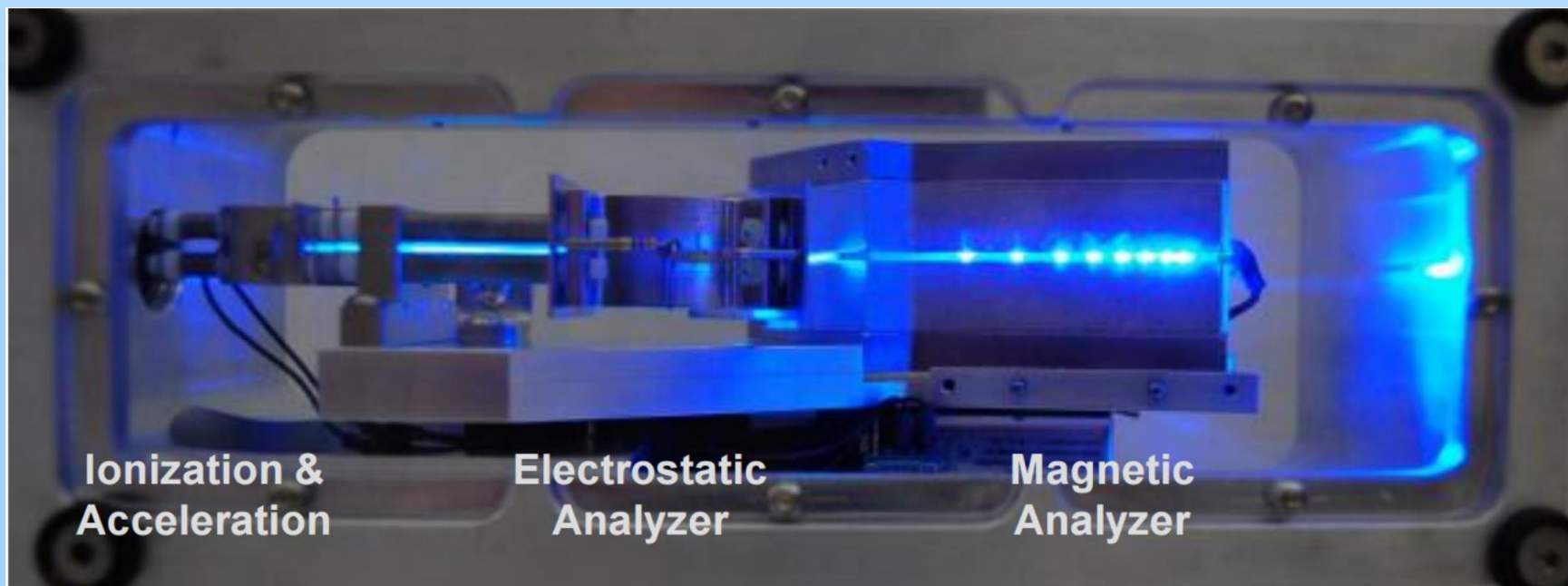


4000 MiD Bringing mass spectrometry down to size

www.microsaic.com



Self-contained instrument
Embedded PC
Vacuum inlet flow 2 mL/min
24V input (battery operation)



**Ionization &
Acceleration**

**Electrostatic
Analyzer**

**Magnetic
Analyzer**

Advion expression Compact Mass Spectrometer



www.advion.com

Microscale Ion Trap

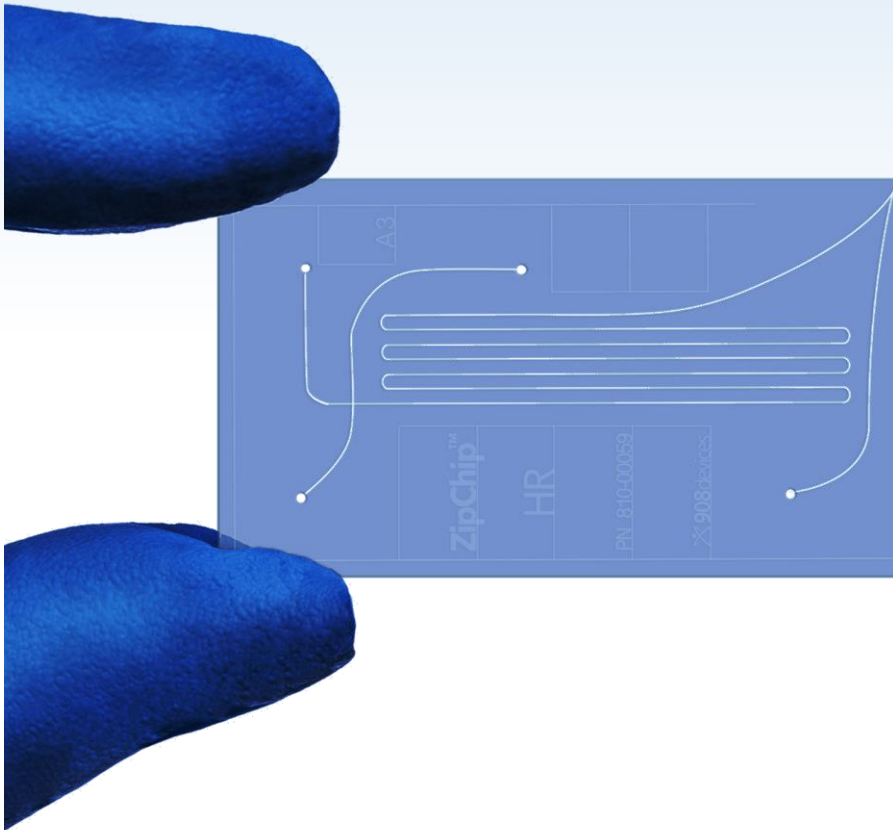


Internal glow discharge ionization
Mass Range 15-450 amu
Mass Resolution 1 amu



<http://908devices.com/>

Automated CE-MS on a glass chip



Patent? Patent!

What is a patent

Invention disclosure

Does it make sense to patent?

Patent search

Resources

What Is a Patent?

A patent for an invention is the **grant of a property right to the inventor**, issued by the United States Patent and Trademark Office. Generally, the **term of a new patent is 20 years** from the date on which the application for the patent was filed in the United States or, in special cases, from the date an earlier related application was filed, subject to the **payment of maintenance fees**. U.S. patent grants are effective only within the United States, U.S. territories, and U.S. possessions. Under certain circumstances, patent term extensions or adjustments may be available.

What is granted is not the right to make, use, offer for sale, sell or import, but the right to exclude others from making, using, offering for sale, selling or importing the invention. Once a patent is issued, the patentee must enforce the patent without aid of the USPTO.

There are **three types of patents**:

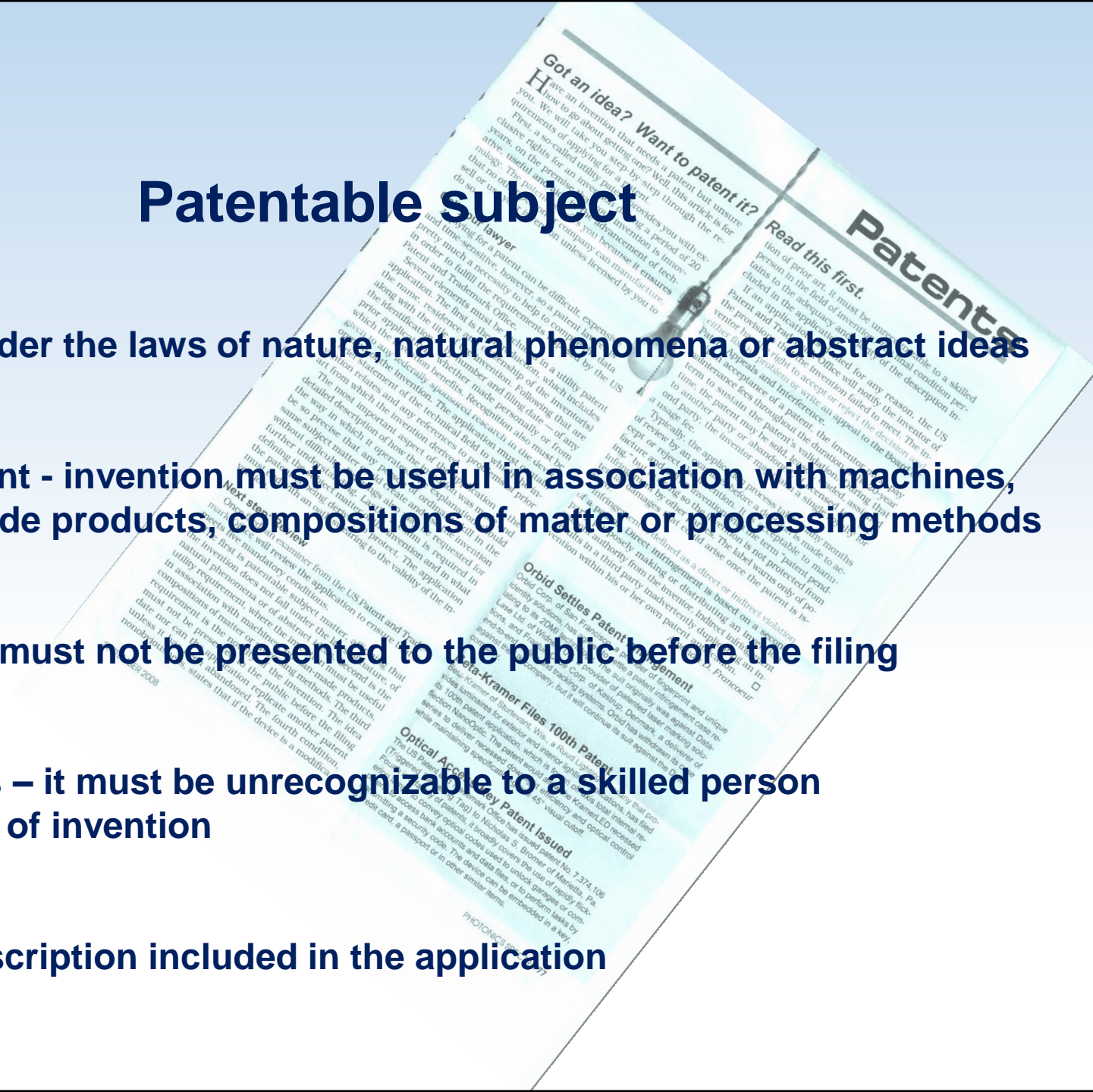
1) **Utility patents** may be granted to anyone who invents or discovers any new and **useful process, machine, article of manufacture, or composition of matter**, or any new and useful **improvement thereof**;

2) **Design** patents may be granted to anyone who invents a new, original, and ornamental **design for an article of manufacture**; and

3) **Plant patents** may be granted to anyone who **invents or discovers and asexually reproduces any distinct and new variety of plant**.

Patentable subject

1. Does not fall under the laws of nature, natural phenomena or abstract ideas
2. Utility requirement - invention must be useful in association with machines, human-made products, compositions of matter or processing methods
3. Novelty the idea must not be presented to the public before the filing
4. Nonobviousness – it must be unrecognizable to a skilled person in the field of invention
5. Clarity of the description included in the application



Patent je zákonná ochrana vynálezů zaručující vlastníkov patentu výhradní právo k průmyslovému využití vynálezu.

V České republice udělování patentů upravuje zákon 527/1990. Podle něj se patenty udělují na vynálezy, které **jsou nové, jsou výsledkem vynálezecké činnosti a jsou průmyslově využitelné.**

Vynález se považuje za nový, jestliže není součástí stavu techniky.

Stavem techniky je všechno, co bylo zveřejněno přede dnem přihlášení patentu, ať již v České republice nebo v zahraničí.

Za vynálezy se naopak nepovažují zejména :

**objevy, vědecké teorie a matematické metody,
pouhé vnější úpravy výrobků,
plány, pravidla a způsoby vykonávání duševní činnosti,
programy počítačů,
pouhé uvedení informace**

Majitel patentu má výlučné právo vynález využívat (tj. výrobek vyrábět, uvádět do oběhu nebo upotřebit postup), dále poskytnout souhlas k využívání vynálezu jiným osobám (např. licenční smlouvou) a má právo převést patent na jinou osobu.

Proto, aby patent zůstal v platnosti, je nutno platit tzv. udržovací poplatky, a to v každém státu zvlášť. Maximální možná délka patentové ochrany je 20 roků.

United States Patent and Trademark Office

www.uspto.gov

European patent office

www.epoline.org

Úřad průmyslového vlastnictví

www.upv.cz

Patents

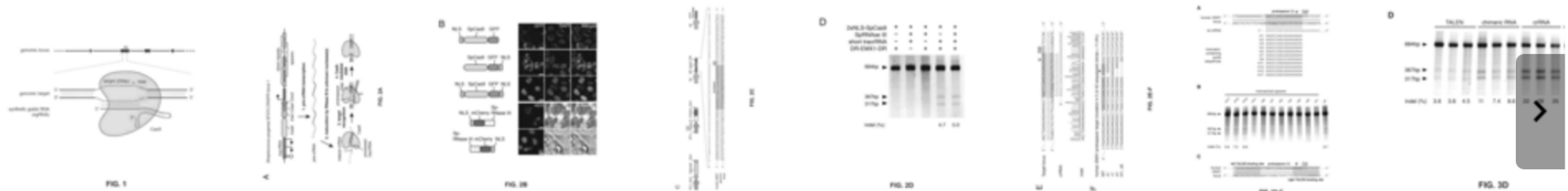
CRISPR-Cas systems and methods for altering expression of gene products

US 8697359 B1

ABSTRACT

The invention provides for systems, methods, and compositions for altering expression of target gene sequences and related gene products. Provided are vectors and vector systems, some of which encode one or more components of a CRISPR complex, as well as methods for the design and use of such vectors. Also provided are methods of directing CRISPR complex formation in eukaryotic cells and methods for utilizing the CRISPR-Cas system.

IMAGES (46)



DESCRIPTION

RELATED APPLICATIONS AND INCORPORATION BY REFERENCE

This application claims priority to U.S. provisional patent application 61/842,322, entitled **CRISPR-CAS SYSTEMS AND METHODS FOR ALTERING**

Publication number US8697359 B1
Publication type Grant
Application number US 14/054,414
Publication date 15 Apr 2014
Filing date 15 Oct 2013
Priority date 12 Dec 2012

Also published as [CA2894688A1](#), [13 More »](#)

Inventors [Feng Zhang](#)

Original Assignee [The Broad Institute, Inc., Massachusetts Institute Of Technology](#)

Export Citation [BiBTeX](#), [EndNote](#), [RefMan](#)

[Patent Citations](#) (9), [Non-Patent Citations](#) (9), [Referenced by](#) (79), [Classifications](#) (44), [Legal Events](#) (5)

External Links: [USPTO](#), [USPTO Assignment](#), [Espacenet](#)

CLAIMS (20)

What is claimed is:

1. A method of altering expression of at least one gene product comprising introducing into a eukaryotic cell containing and expressing a DNA molecule



US00D366297S

United States Patent [19]**Ford**[11] **Patent Number:** **Des. 366,297**[45] **Date of Patent:** **Jan. 16, 1996**[54] **FINGER PUPPET**[75] **Inventor:** **Hobart Ford**, 62 Ballard Ranch Rd.,
Weaverville, N.C. 28787[73] **Assignees:** **Hobart Ford**, Weaverville, N.C.;
Regina Marscheider, Virginia Beach,
Va.[**] **Term:** **14 Years**[21] **Appl. No.:** **20,759**[22] **Filed:** **Apr. 1, 1994**[52] **U.S. Cl.:** **D21/153; D21/189**[58] **Field of Search** **D21/148, 149,**
D21/152, 153, 189-190; 446/71, 72, 83,
97, 268, 392, 327[56] **References Cited****U.S. PATENT DOCUMENTS**

D. 55,960	8/1920	Simon	D21/190
D. 177,082	3/1956	Wolf	D21/190
1,329,509	2/1920	Dane et al.	D21/190
1,794,036	2/1931	Scott	D21/189
4,019,570	3/1977	Kohler	446/327
4,304,065	12/1981	Batera	446/327

4,409,754 10/1983 Moreau 446/392

FOREIGN PATENT DOCUMENTS431066 8/1911 France 446/392
753289 8/1933 France 466/392*Primary Examiner*—Sandra L. Morris
Attorney, Agent, or Firm—Lowe, Price, LeBlanc & Becker[57] **CLAIM**

The ornamental design for a finger puppet, as shown and described.

DESCRIPTION

FIG. 1 is a reduced perspective view of a finger puppet, showing my new design, the broken line showing of a hand is for illustrative purposes only, and forms no part of the claimed design;

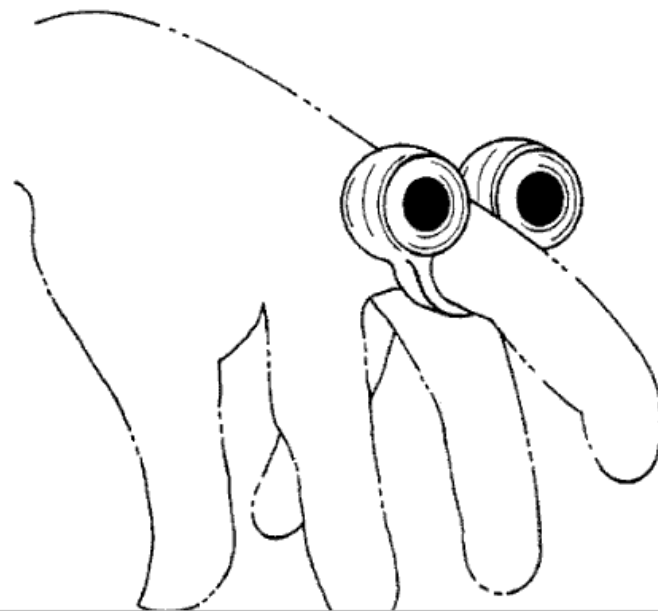
FIG. 2 is a front elevational view thereof;

FIG. 3 is a rear elevational view thereof;

FIG. 4 is a bottom plan view thereof;

FIG. 5 is a top plan view thereof; and,

FIG. 6 is a side elevational view thereof, both sides being of the same appearance.

1 Claim, 1 Drawing Sheet



CTT

Centrum pro transfer
technologií

• Biomechanická obuv pro zdravější chůzi



Domů

Domů

Služby

Duševní vlastnictví

Příklady dobré praxe

Nabídka vzdělávání

Ke stažení

Novinky a akce

Newsletter INTERFACE

O nás

Rada pro komercializaci

Fotogalerie

Kontakt

Firmy a firemní zákazníci

Vědci a studenti univerzity

Centrum pro transfer technologií Masarykovy univerzity (CTT) bylo založeno v roce 2005 s jednoznačným posláním: podporovat uplatnění výsledků vědy a výzkumu v praxi, budovat mosty mezi akademickou a soukromou sférou, nastavovat podmínky pro transfer technologií a znalostí, chránit a spravovat duševní vlastnictví MU a poskytovat vědcům i firmám profesionální podporu a servis ve všech souvisejících oblastech.

Tým CTT je tvořen business development manažery, projektovými manažery, právníky a ekonomicko-administrativním zázemím. Portfoliem svých služeb tito specialisté oslovují jak vědce MU, tak komerční firmy. Jaké jsou základní úkoly pracoviště?

- primární kontaktní místo Masarykovy univerzity pro firmy
- zprostředkování spolupráce akademické a podnikatelské sféry
- podpora uplatnění výsledků výzkumu v praxi
- ochrana a správa duševního vlastnictví
- propagace výzkumných aktivit Masarykovy univerzity
- vzdělávání a poradenství v oblasti transferu technologií a duševního vlastnictví

Více informací o transferu technologií na Masarykově univerzitě se dozvíte z brožury CTT. Příslušnou jazykovou verzi otevřete kliknutím na obrázek.



Česká verze brožury



Anglická verze brožury

www.ctt.muni.cz



Novinky a akce

9.11.2016

Vychází druhý letošní INTERFACE

Právě vychází druhé letošní číslo zpravodaje INTERFACE, který vydává Centrum pro...

2.11.2016

TT Day 2016: Vstupte do světa inovací!

Centrum pro transfer technologií si Vás dovoluje pozvat na 4. den otevřených dveří ...

31.10.2016

Pozor na podvodné prodlužování ochranných známek!

Na CTT MU opět přišly dokumenty, které se tváří jako výzva k prodloužení ochranné...

13.10.2016

MU spolupořádá konferenci o mezinárodních dotačních programech

Masarykova univerzita zve jako spolupořadatel na konferenci s názvem "Neříkejte NE..."

Kontakt

Masarykova univerzita
Centrum pro transfer technologií

Komenského náměstí 2
602 00 Brno
tel.: +420 549 49 8016
fax: +420 549 49 1022
e-mail: ctt@ctt.muni.cz

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DIČ: CZ00216224

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Brno, October 15 - 17, 2018

**Brno, No. 27 on the list of 52 places
to visit in 2016**

The New York Times

www.ce-ce.org